



Dephasing and Disorder Effects in Topological Systems

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Outline



➤ Introduction

- ❑ From quantum Hall systems to topological insulators

➤ Dephasing effects in topological insulators

- ❑ Edge states of 2D quantum spin Hall insulators

- ❑ Surface states of 3D topological insulators

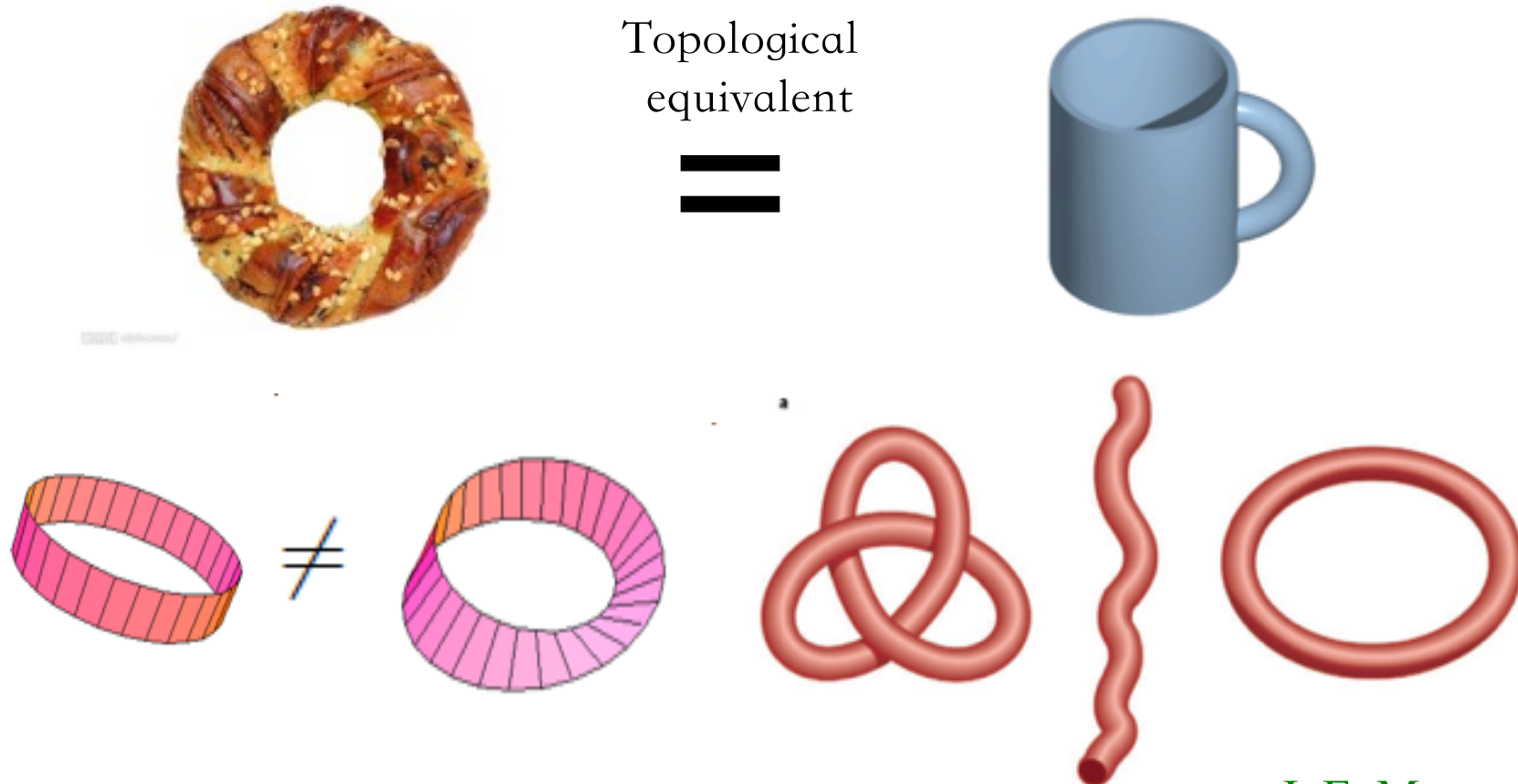
➤ Disorder effects in topological insulators

- ❑ Tunable Anderson transition in 2D quantum spin Hall insulators

- ❑ Multiple Anderson transition in Weyl semimetals

Topology

□ Topology: an area of mathematics concerned with the properties of space that are preserved under continuous deformations.



J. E. Moore, Nature (2010)

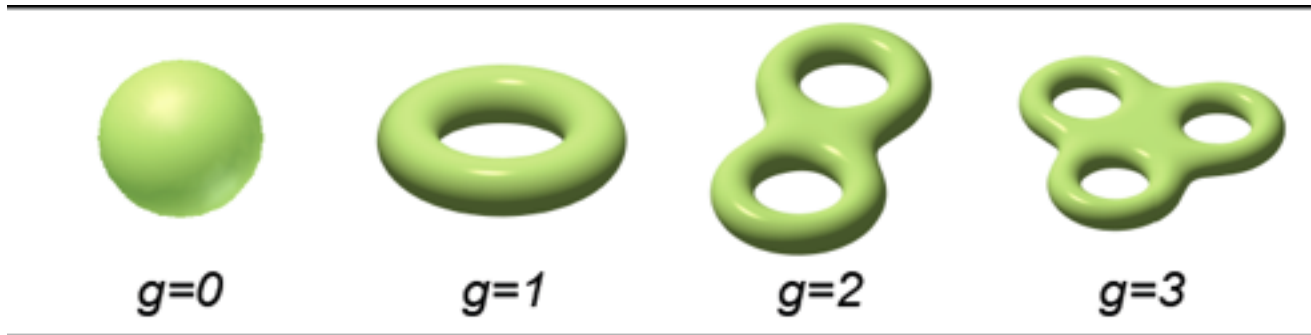
Topological invariant

□ Topological invariant: invariant under continuous transformation

Gauss-Bonnet-Chern formula:

$$\frac{1}{2\pi} \int_S K dA = 2(1 - g)$$

K : Gauss curvature g : genus



Shiing-Shen Chern
陈省身先生

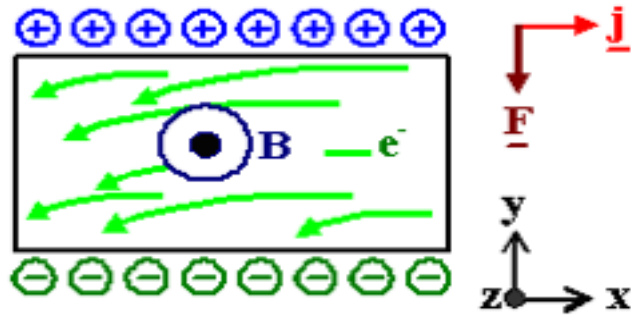
□ Connect the geometry to the topology.

□ For 2D compact manifold, the topological invariant is the genus or Euler characteristic.

Hall effect

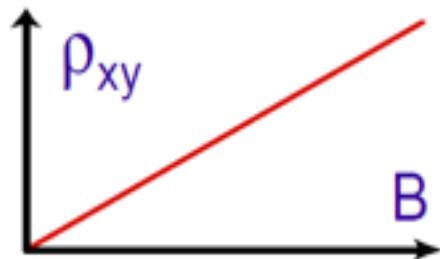


Edwin Hall
(1879)



Hall resistance

$$\rho_{xy} = \frac{E_y}{J_x} = \frac{B}{nq}$$



Charge carrier is subjected to the electric field force and Lorentz force:

$$\vec{F} = \vec{F}_e + \vec{F}_m = q(\vec{E} + \vec{v} \times \vec{B})$$

For steady state, the resultant force in y direction is zero.

$$F_y = 0 \quad E_y = v_x B_z$$

Current density
in x direction

$$J_x = nq v_x$$

q = carrier charge n = carrier density

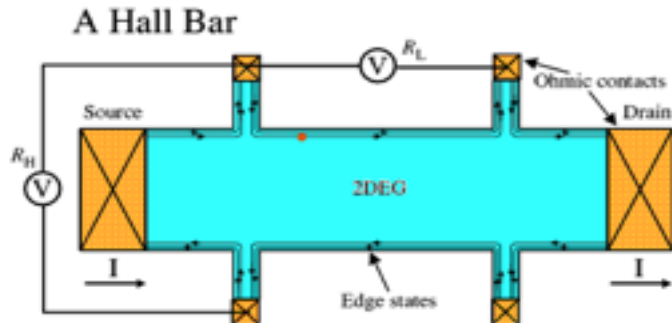
Hall resistivity

$$\rho_{xy} = \frac{E_y}{J_x} = \frac{B}{nq}$$

Application of Hall measurement:

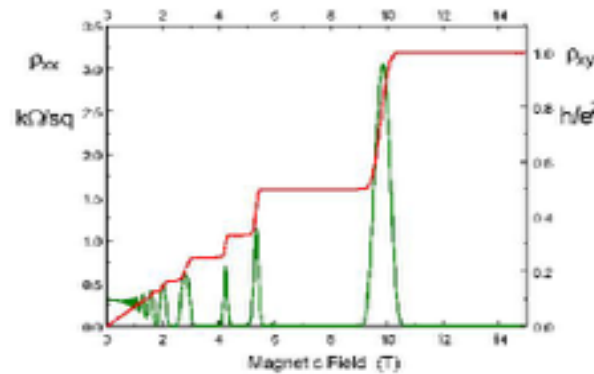
- ☐ measure the carrier density.
- ☐ ascertain the carrier type. electron ($e < 0$) hole ($q > 0$)

Quantum Hall effect



Under low temperatures and strong magnetic fields, the Hall conductance take on the quantized values.

$$\rho_{xy} = R_Q / n \quad n = \text{integer}$$



R_Q Resistance quantum

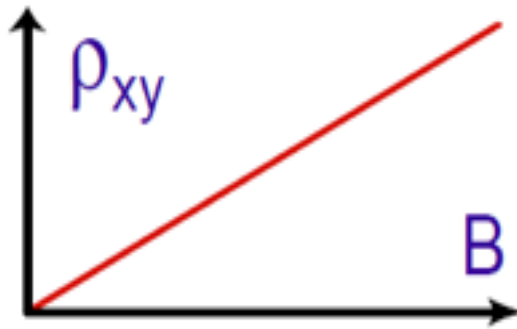
$$R_Q = h / e^2 = 25.812\,807 \text{ k}\Omega$$

K.Von klitzing
(1980)

Quantum Hall effect

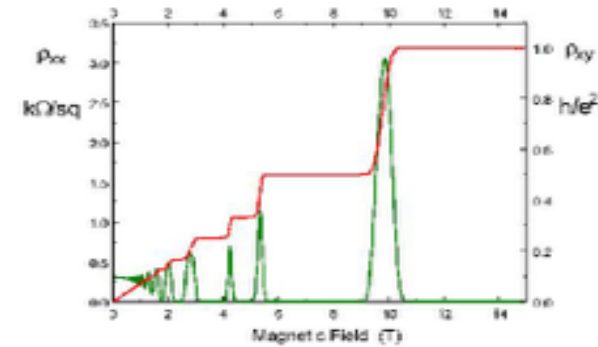
- Quantum Hall state provided the first example of a quantum state topologically distinct from all states of matter known before.

Normal physical quantities



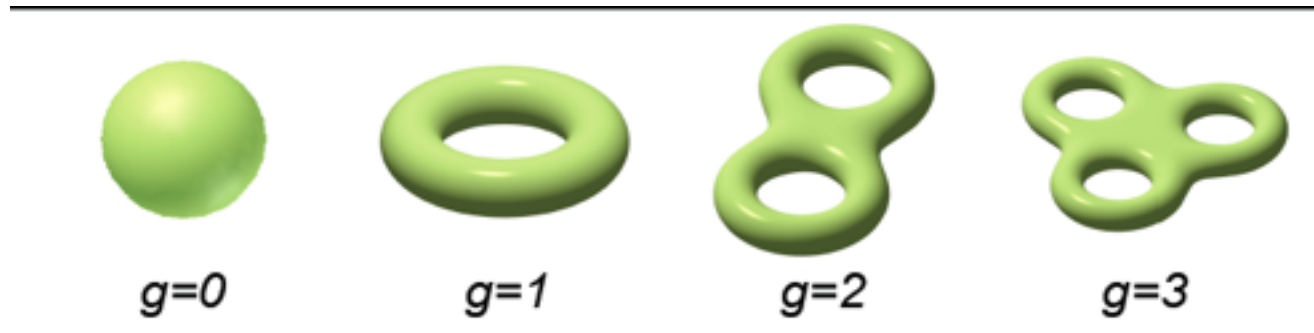
Small perturbations to the system
Small changes of physical quantities.

Quantum Hall effect

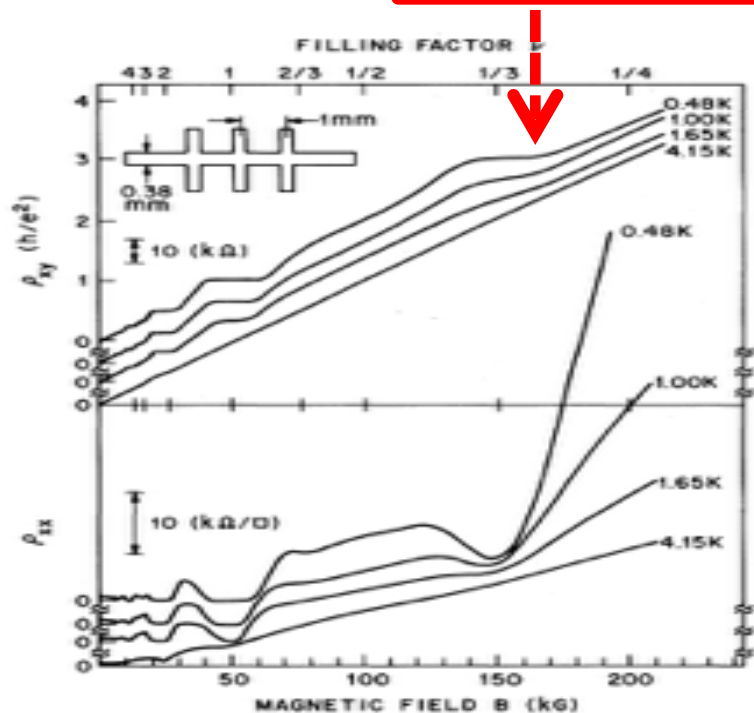


Hall resistance does not change
at all if the perturbation is small

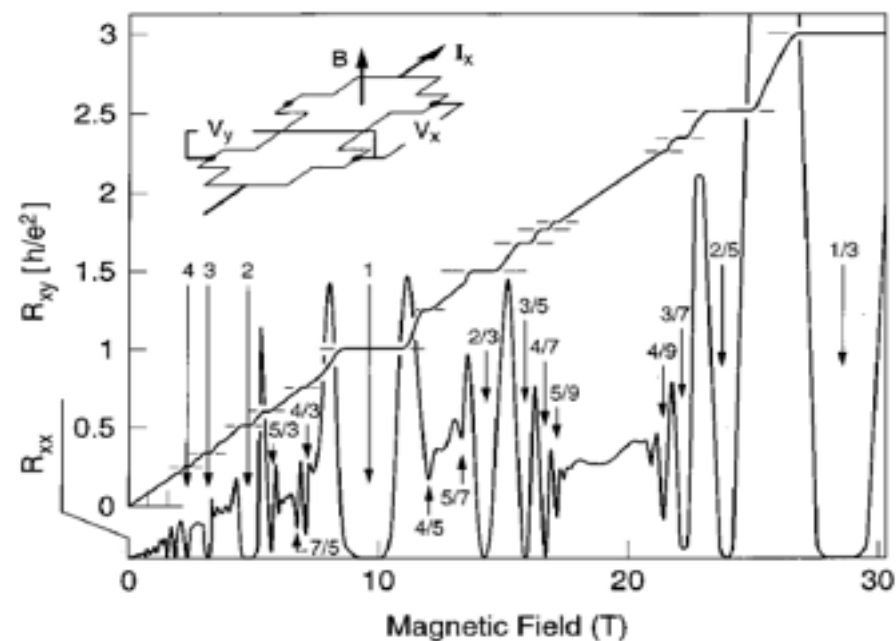
- The physical quantities are related to topological invariants



分数量子霍尔效应



D. C. Tsui, H. L. Stomer et al (1982)



J. P. Eisenstein et al., (1990)

➤ 从整数量子霍尔效应到分数量子霍尔效应

❑ 更高质量的样品，更强的磁场，更低的温度

❑ 霍尔电阻分数量子化。 $\rho_{xy} = (p/q)R_Q$

p, q 为正整数

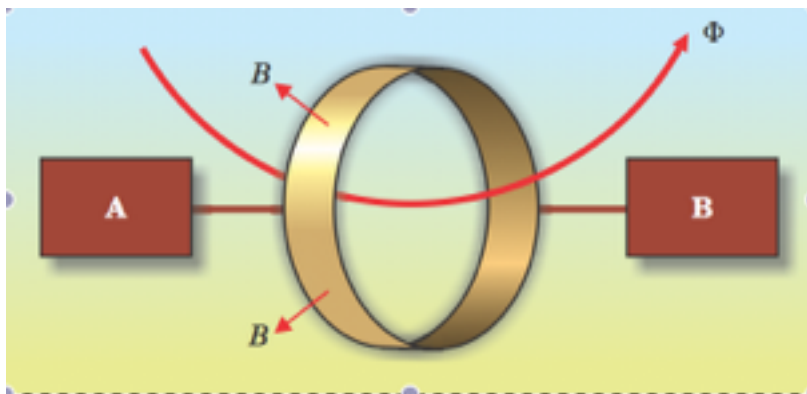
➤ 理论方面

❑ 电子在强磁场和相互作用下的集体行为.

❑ 准粒子带有分数电荷 e/q

Topological origin of Quantum Hall effect

Laughlin's gedanken experiment



□ Adding $\Delta\phi = hc/e$ maps the system back to itself

□ The energy increase satisfy

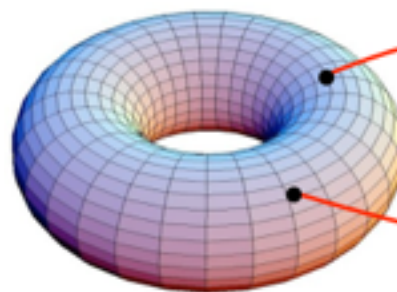
$$I = c \frac{neV}{\Delta\phi} = \frac{ne^2 V}{h}.$$

□ n is an arbitrary integer

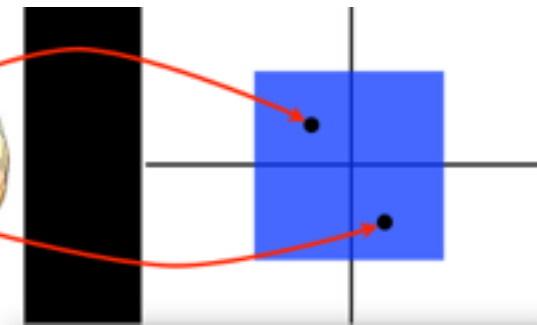
R. B. Laughlin, PRB (1981)

TKNN number (Chern number)

Bloch Bands



Brillouin zone



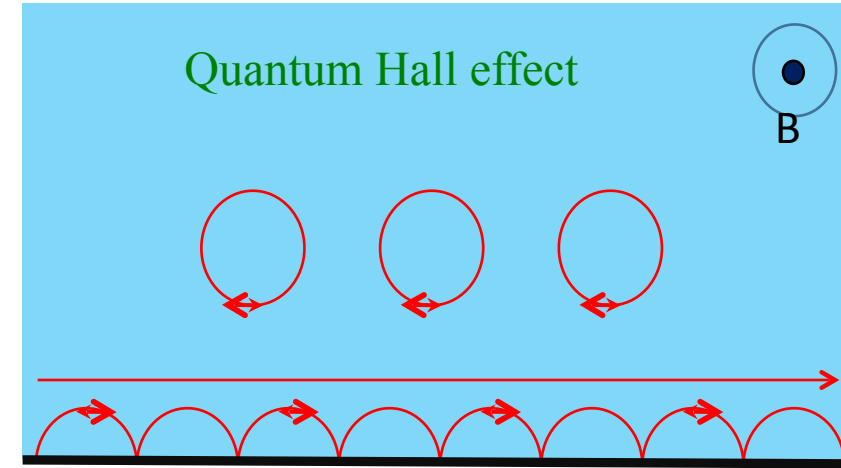
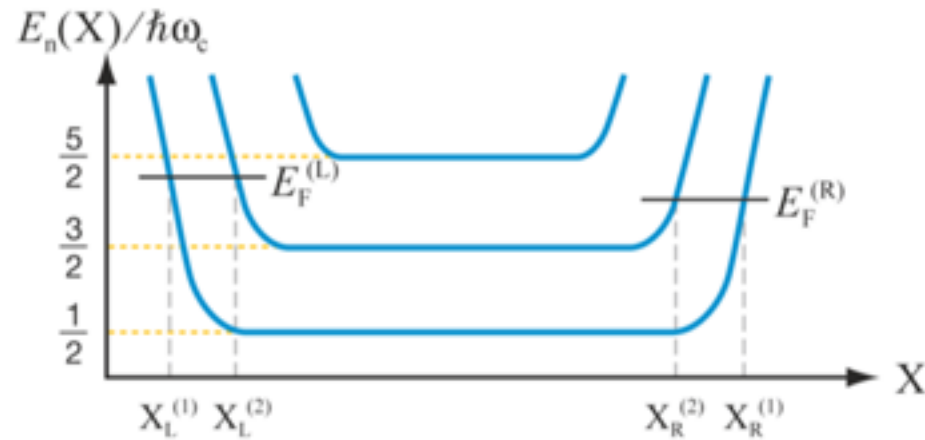
Bloch Bands $|\psi_n(\mathbf{q})\rangle = |\psi_n(\mathbf{q} + \mathbf{G})\rangle$

$$\sigma_{xy} = \frac{e^2}{\hbar} \int_{\text{BZ}} \frac{d^2k}{(2\pi)^2} \Omega_{k_x k_y} = n \frac{e^2}{h}$$

□ The Hall conductance is **topological invariant (Chern number)**, which can **only take integer values**.

TKNN, PRL (1982)

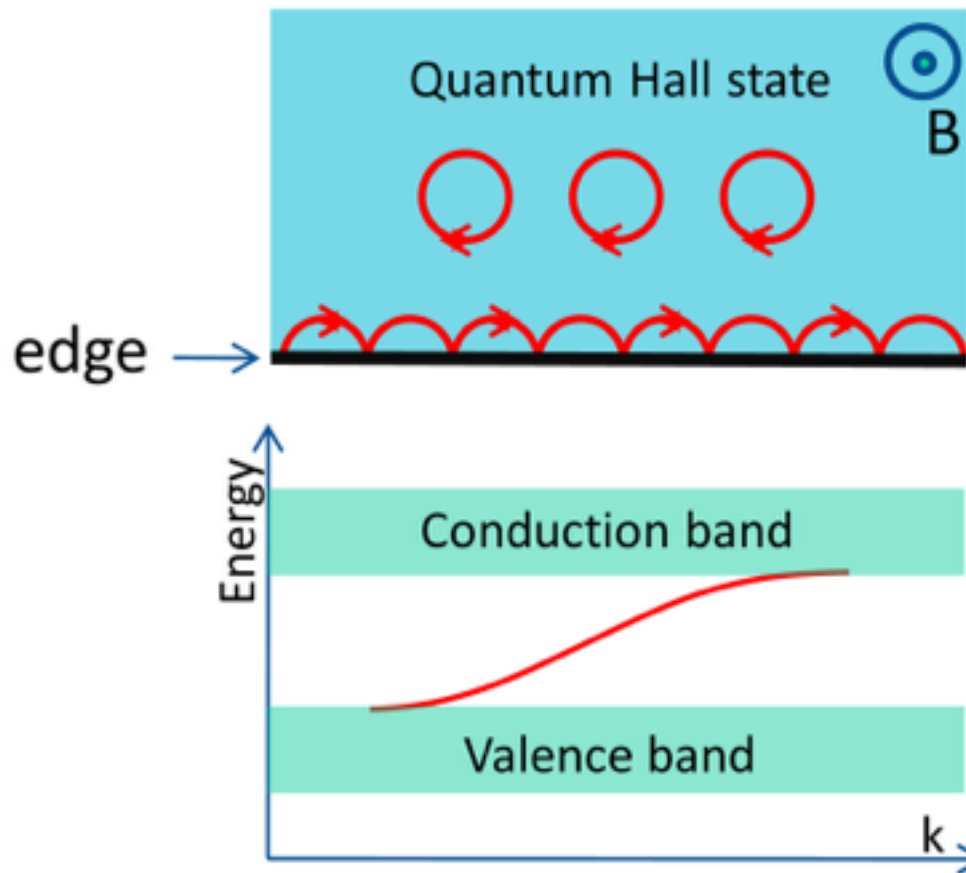
Edge states in Quantum Hall effect



- ❑ The bulk states form **Landau Levels**
- ❑ The **bulk** of the sample is **insulator**, but it is **distinct** from normal insulator. The **current flow on the edge** of the sample.
- ❑ **Chiral** edge transport

Quantum Hall effect →

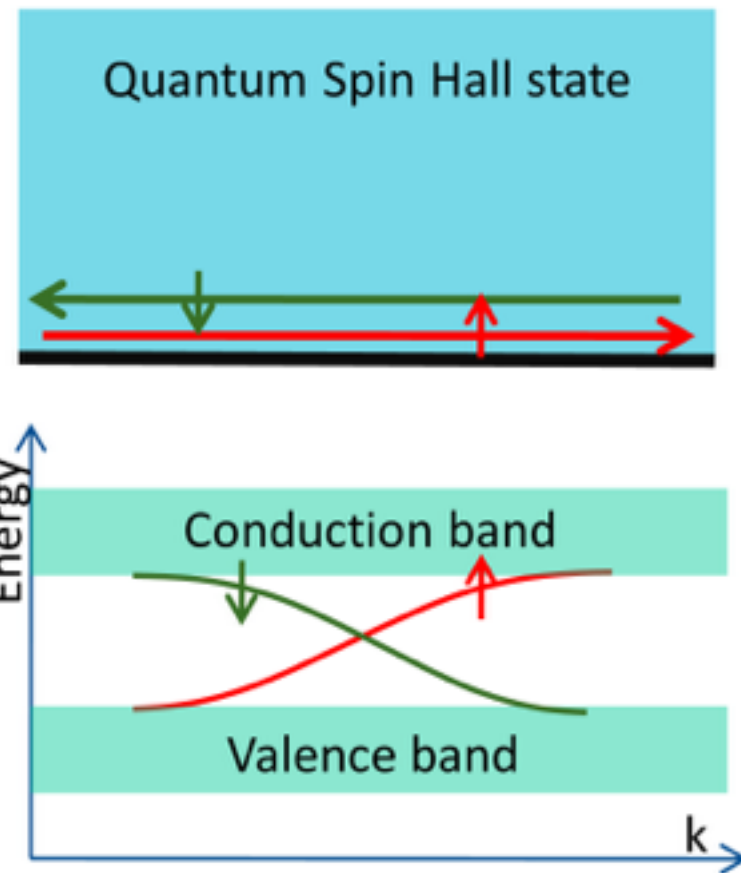
Quantum spin Hall effect



Chiral edge states.

Break TRS with B or M .

No backscattering.



Helical edge states.

Preserve time reversal symmetry (TRS).

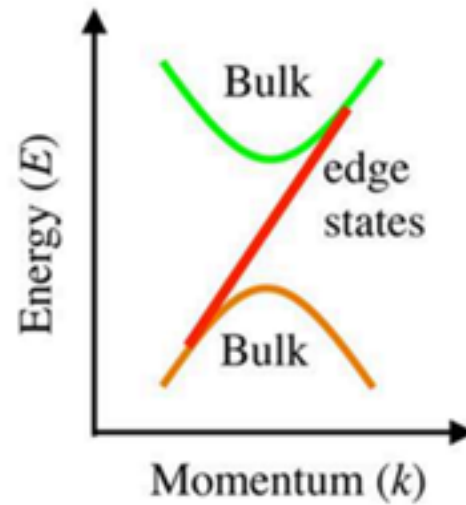
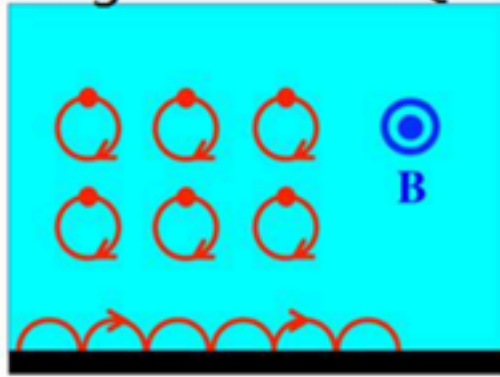
No backscattering for TRS perturbations.

CL Kane, EJ Mele, PRL, 95, 226801, (2005).

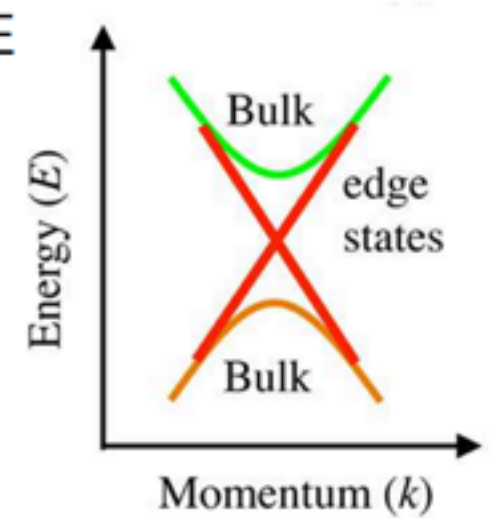
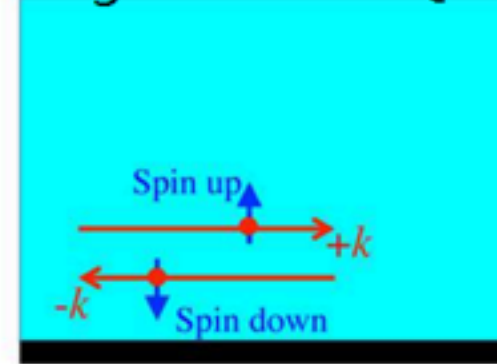
BA Bernevig, TL Hughes, SC Zhang, Science, 314, 1757 (2006).

Quantum Hall effect $\rightarrow$ Z2 Topological Insulator

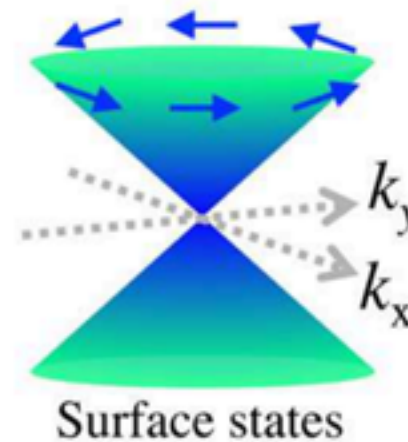
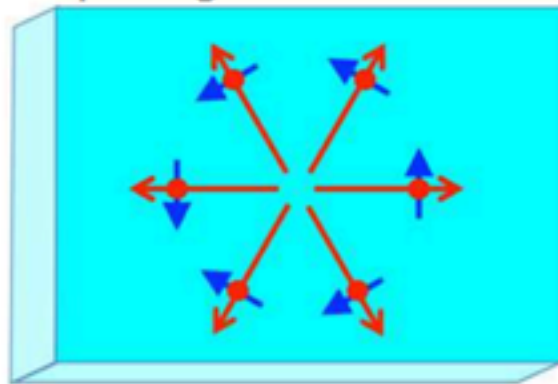
a Edge states in QH



b Edge states in QSHE

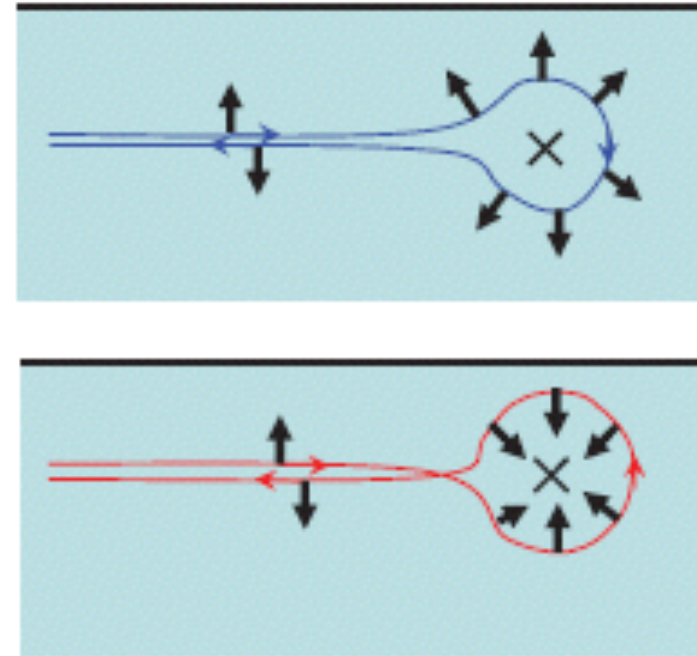
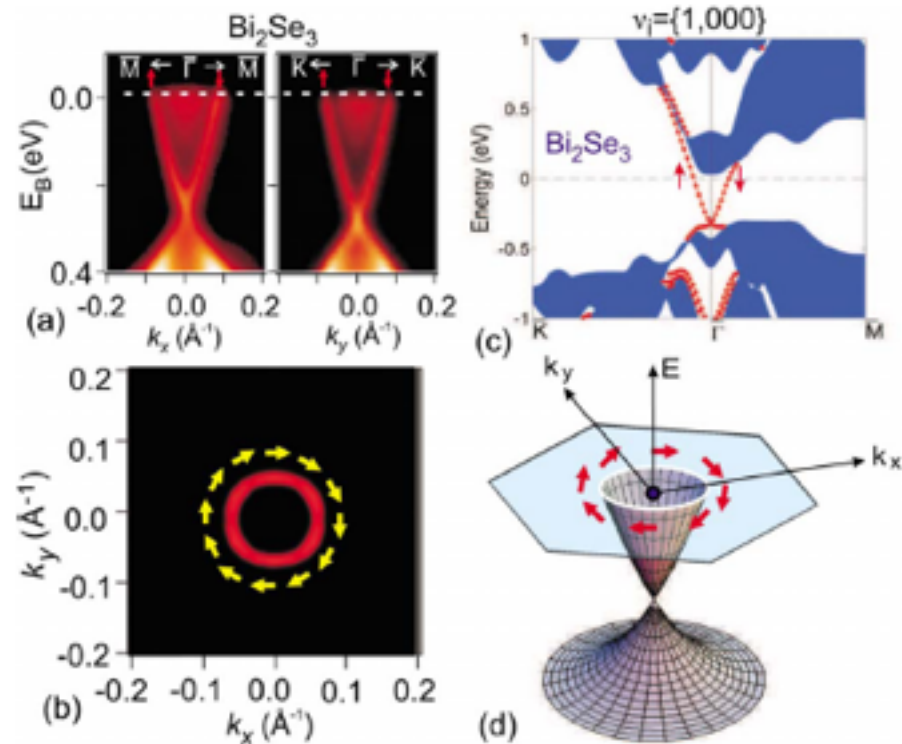


c Topological surface states



M. Z. Hasan et. al. (review) arXiv: 1406.1040v1.

Helical surface states of 3D strong topological insulator



Gapless surface states

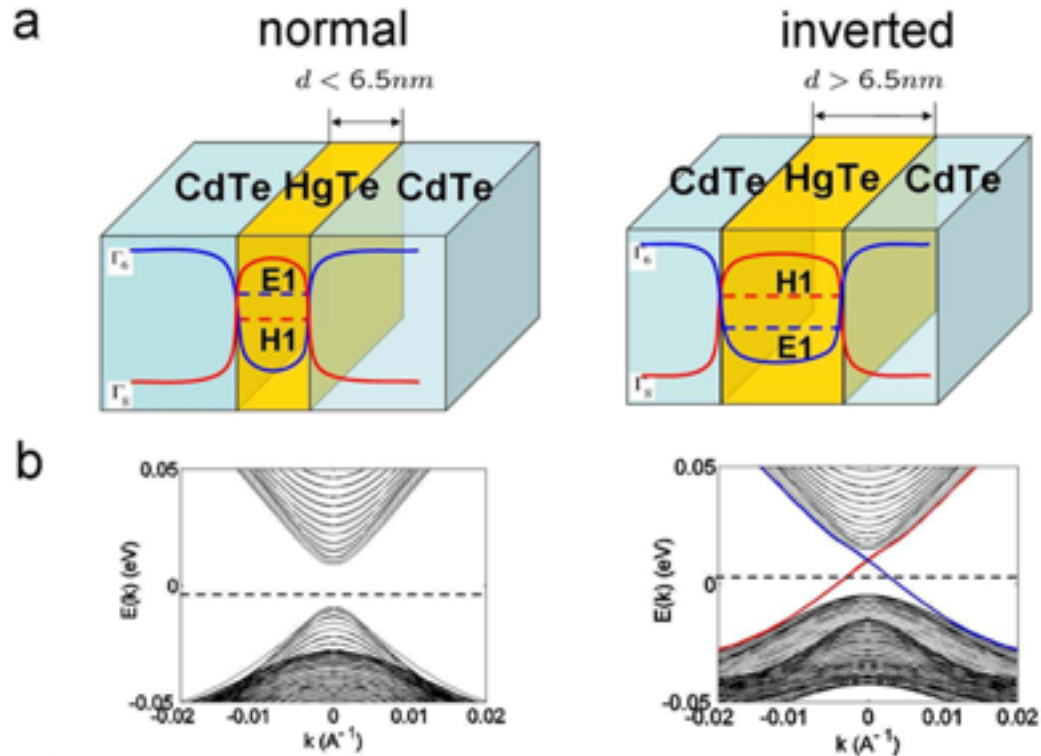
No backscattering for nonmagnetic impurities.

M. Z. Hasan and C. L. Kane, Rev. Mod. Phys. 82, 3045 (2010).

X. L. Qi and S. C. Zhang, Rev. Mod. Phys. 83, 1057 (2011).

Realization of Quantum spin Hall effect

HgTe/CdTe quantum wells

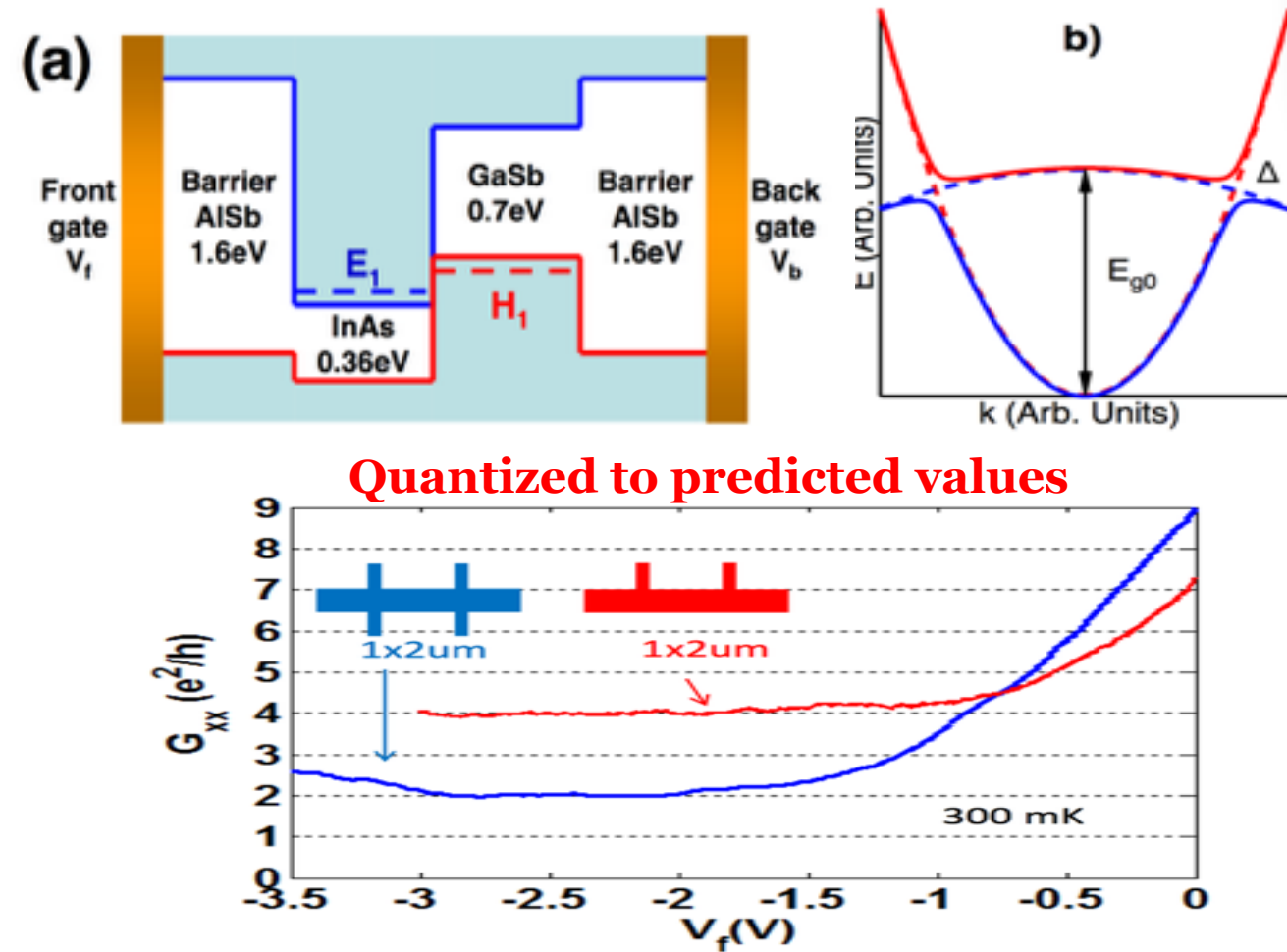


Normal insulator

QSHE

B.A Bernevig et al., Science 314,1757 (2006)

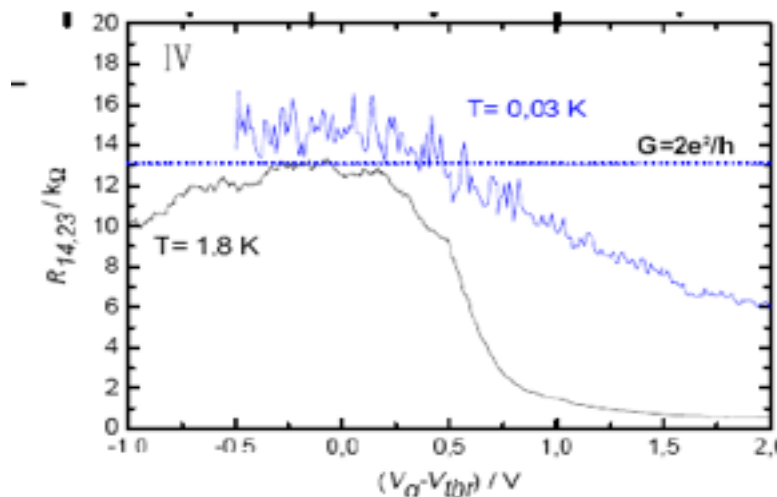
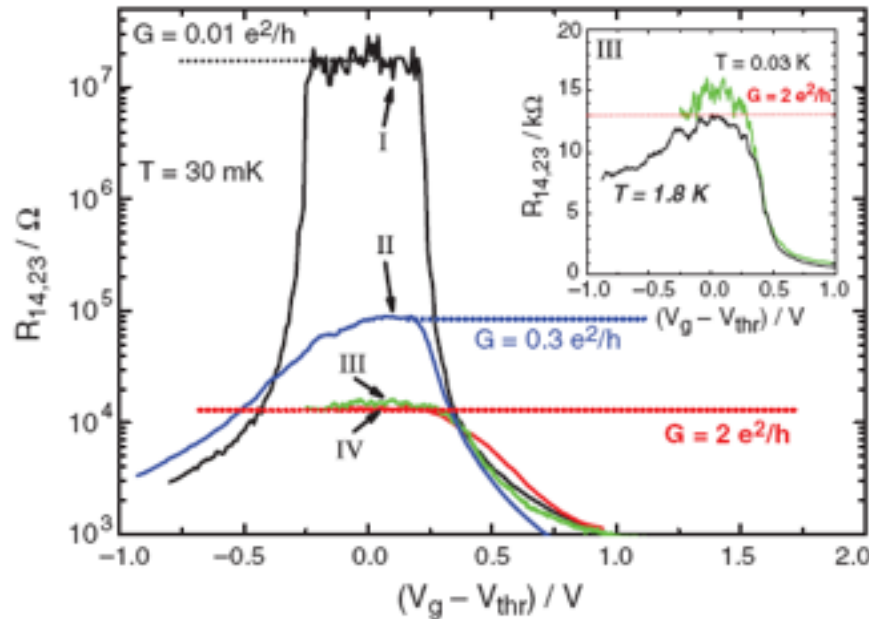
InAs/GaSb quantum wells



Ivan Knez et al., Phys. Rev. Lett. 107, 136603 (2011)
L. J. Du et al., arxiv:1306.1925v1 (2013)

Transport measurement of QSHE

HgTe/CdTe Quantum well



➤ $d < d_c$ normal insulator

➤ $d > d_c$ 2D Topological insulator

□ In small samples, $R_{14,23}$ is quantized, insensitive to W variations.

□ In large samples, $R_{14,23}$ is no longer quantized. **Why?**

□ QSH signal is robust against temperature change.

M König, et al., Science 318, 766 (2007).

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Dephasing effects on 2D quantum Spin hall insulators

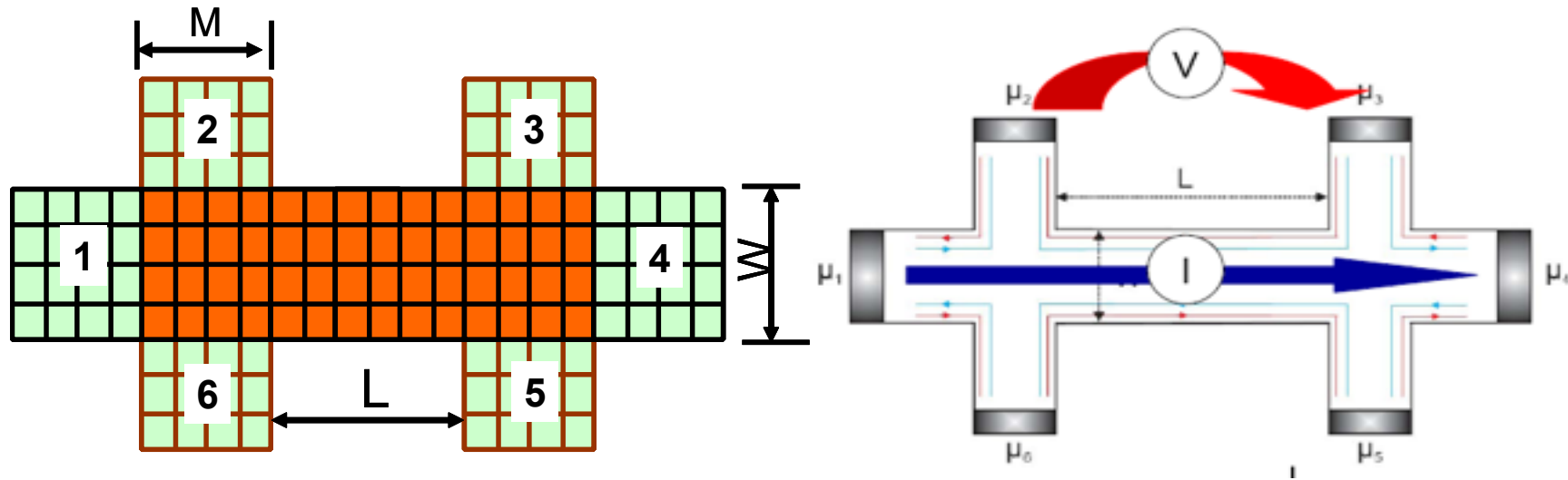
Try to answer the questions:

- Why longitudinal resistance only quantized in small sample ?
- Is there an observable physical quantity showing a quantized value in macroscopic samples ?

Two types of dephasing

- **Normal dephasing:** the electron-electron and electron-phonon interactions only destroy the electron phase memory. These dephasing strengths increase with rising temperature.
- **Spin dephasing:** Magnetic impurities, nuclear spin fluctuations and normal dephasing with strong spin-orbital interaction may destroy spin memory.

The dephasing mode for a QSHE system



$$H = -\left[\sum_{i,\sigma} t e^{im\sigma\phi} c_{i\sigma}^+ c_{i+\delta_{x\sigma}} + t c_{i\sigma}^+ c_{i+\delta_{y\sigma}} \right] + \sum_{i,k,\sigma} [\epsilon_k a_{k\sigma}^+ a_{lk\sigma} + (t_k c_{i\sigma}^+ a_{k\sigma} + t_k a_{k\sigma}^+ c_{i\sigma})]$$

$$\mathbf{i} = (i_x \quad i_y) \quad t = \hbar^2 / 2m^* a^2, \phi = qB_{eff} a^2 / \hbar$$

- The first term describes QSHE. This term can also describe QHE if the flux is spin independent.
- We use virtual leads to model dephasing processes. M. Buttiker, *Phys. Rev. B* 33 3020 (1986)

H. Jiang, S.G. Cheng, Q.F. Sun, and X.C. Xie, PRL **103**,036803(2009)

Theoretical formalism and dephasing processes

The particle current in the lead-p (real or virtual lead) with spin σ can be expressed

$$I_{p\sigma} = \frac{e^2}{h} \sum_{q \neq p} T_{pq}^{\sigma} (V_{p\sigma} - V_{q\sigma})$$

Here $V_{p\sigma}$ is the spin-dependent bias in lead p. $T_{pq}^{\sigma} = \text{Tr}[\Gamma_{p\sigma} G^r \Gamma_{q\sigma} G^a]$ is the transmission coefficient from the lead q to p with spin σ , where the linewidth functions $\Gamma_{p\sigma} = i[\Sigma_{p\sigma}^r - \Sigma_{p\sigma}^{r+}]$, the Green function $G^r = [G^a]^\dagger = [E_F \mathbf{I} - H_{cen} - \sum_{p\sigma} \Sigma_{p\sigma}^r]^{-1}$, H_{cen} is the Hamiltonian in the central region, and Σ_p^r is the retarded self-energy of lead-p that can be calculated numerically.

First type dephasing processes: normal dephasing

For each virtual lead i

$$I_{i\uparrow} = I_{i\downarrow} \equiv 0 \quad V_{i\uparrow} \neq V_{i\downarrow}$$

The spin flip processes are forbidden.

Second type dephasing processes: spin dephasing

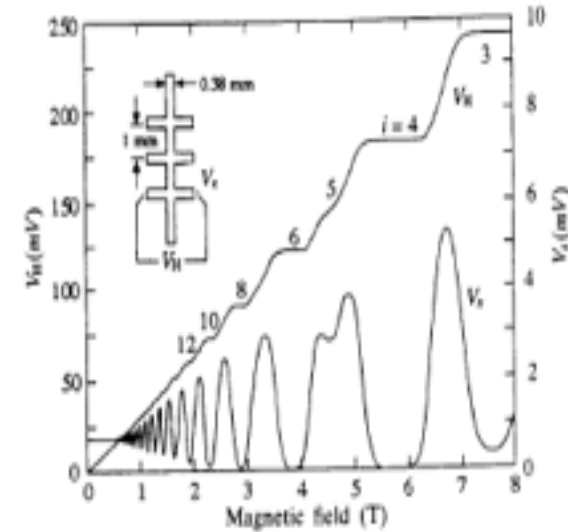
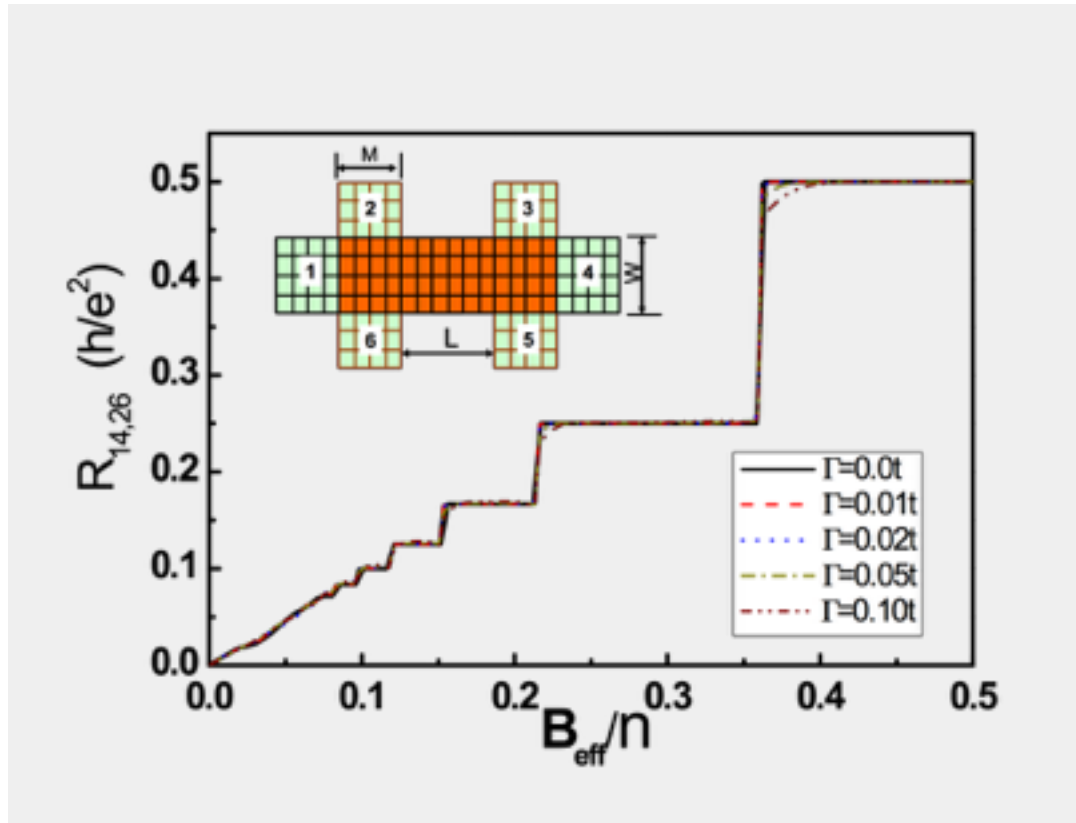
For each virtual lead i

$$I_{i\uparrow} + I_{i\downarrow} \equiv 0 \quad V_{i\uparrow} = V_{i\downarrow}$$

The spin flip processes are allowed.

H. Jiang, S.G. Cheng, Q.F. Sun, and X.C. Xie, PRL **103**,036803(2009)

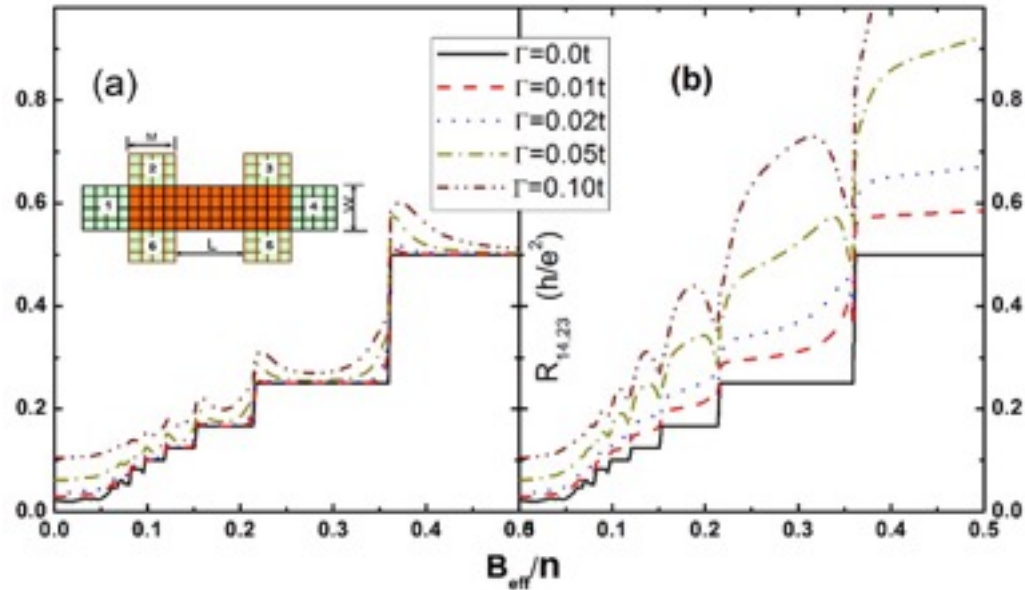
The dephasing in QHE system



$$E_F = -3t, L = 32a, W = 32a, M = 24a$$

- The Fermi energy is fixed near the band bottom.
- The QHE is robust against dephasing.

Dephasing in QSHE system

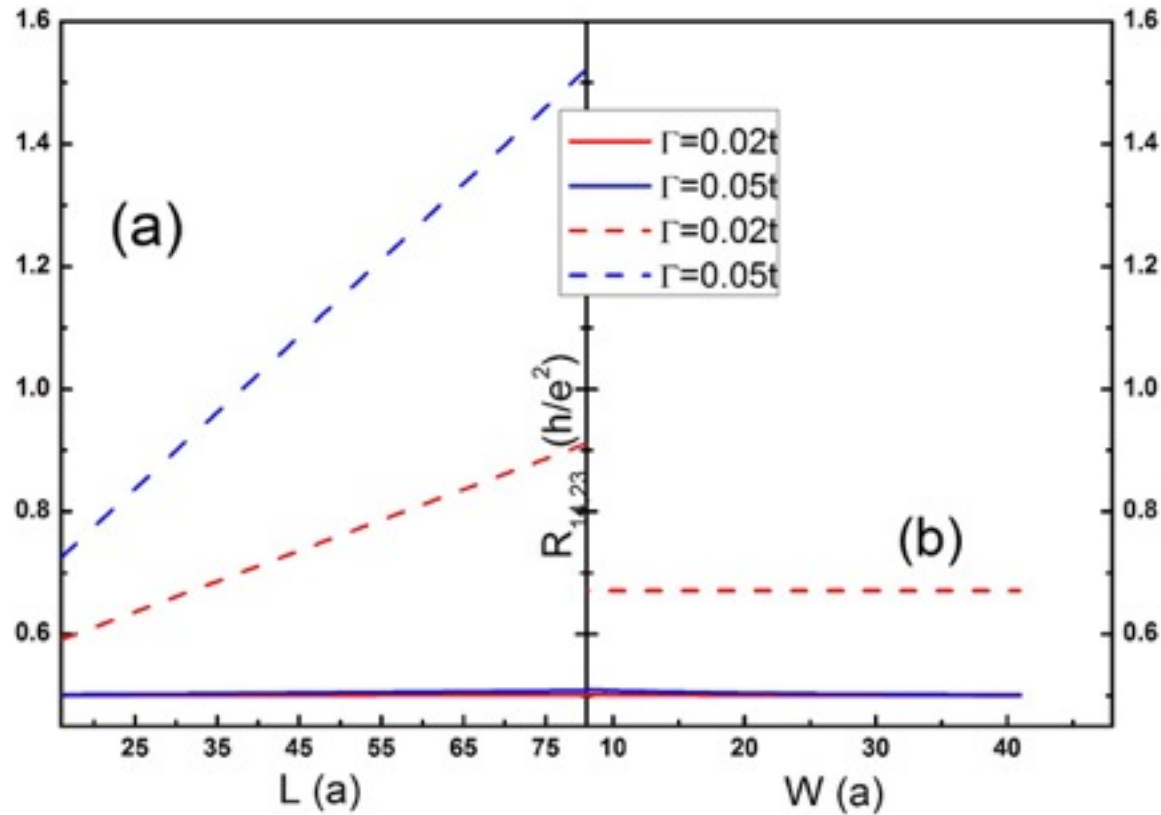


$$E_F = -3t, L = 32a, W = 32a, M = 24a$$

The transport property is robust to normal dephasing, but fragile to spin dephasing.

- Fig.(a) illustrates the normal dephasing while Fig.(b) is for the spin dephasing.
- In the low field, the result is consistent to that of the semi-classical Drude model.
- The dephasing strength is characterized by Γ

Dephasing in QSHE system: II



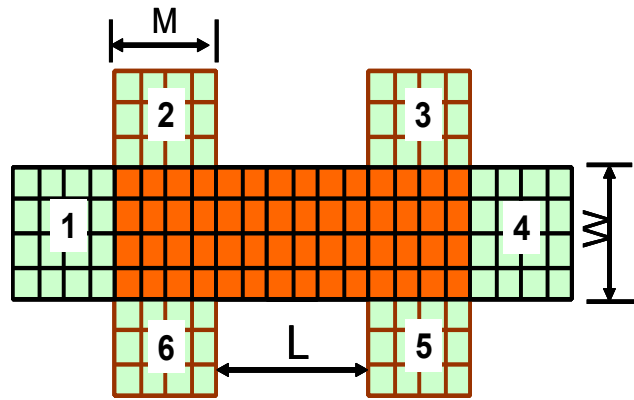
•The dashed line denotes the spin dephasing process, and the solid line denotes the normal dephasing process.

$$E_F = -3t, M = 24a$$

$$B_{\text{eff}} = 0.5, W = 32a \dots (a) B_{\text{eff}} = 0.3, L = 32a \dots (b)$$

The QSH signal is insensitive to width variation but sensitive to the length change.

Spin accumulations: formula and reasoning



Longitudinal leads

$$V_{1\uparrow} = V_{1\downarrow} = -V_{4\uparrow} = -V_{4\downarrow} = V$$

Traverse leads

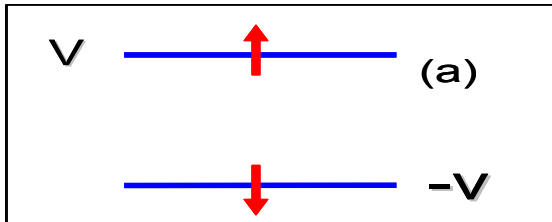
$$I_{p\uparrow} \equiv 0, I_{p\downarrow} \equiv 0, V_{p\uparrow} \neq V_{p\downarrow}$$

resistance

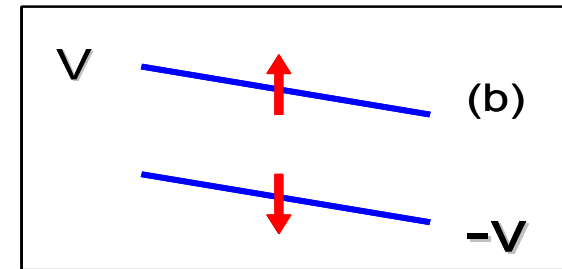
$$R_{p,s} = \frac{V_{p\uparrow} - V_{p\downarrow}}{I_1}$$

for a given edge

in the absence of dephasing



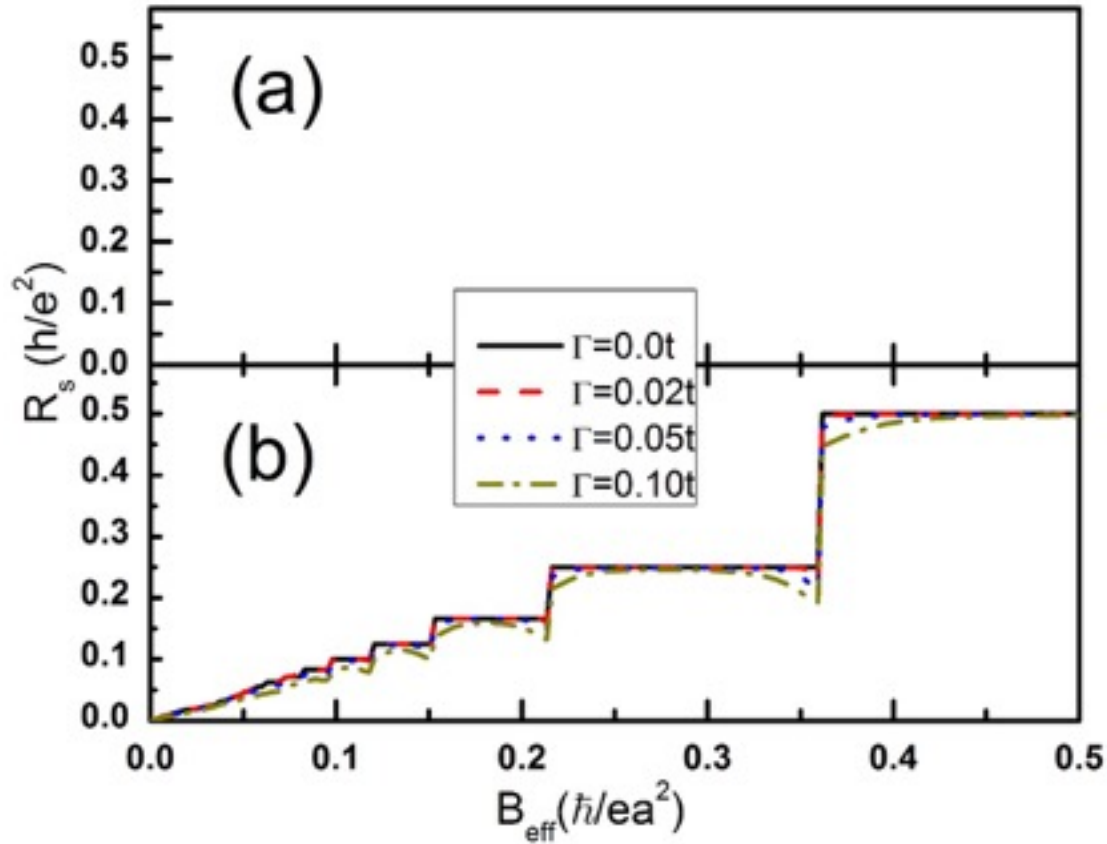
in the present of dephasing



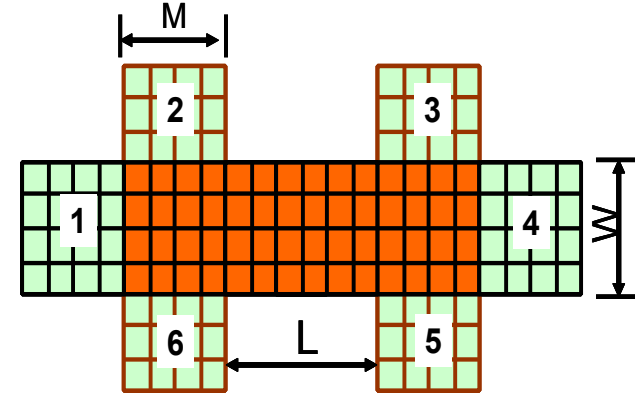
spin flip

$$\begin{matrix} V_{p\uparrow} - V_{p\downarrow} \\ I_1 \end{matrix}$$

Dephasing in QSHE system



$$E_F = -3t, M = 24a, W = 32a, L = 32a$$



$$R_s = (V_{2\uparrow} - V_{2\downarrow})/I_{14}$$

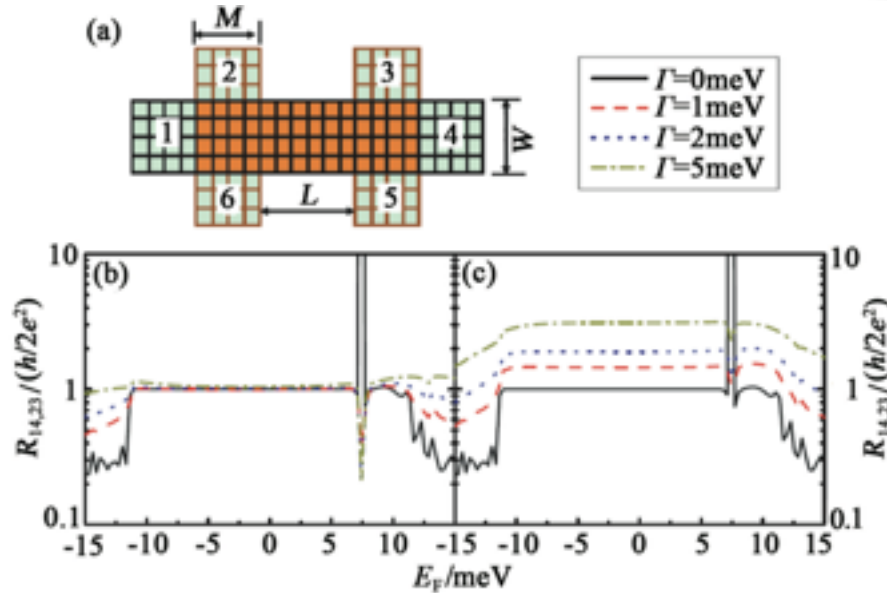
R_s is robust against any dephasing processes

$$R_{2,s} = R_{3,s} = -R_{5,s} = -R_{6,s}$$

Dephasing in QSHE system IV: HgTe/CdTe QWs

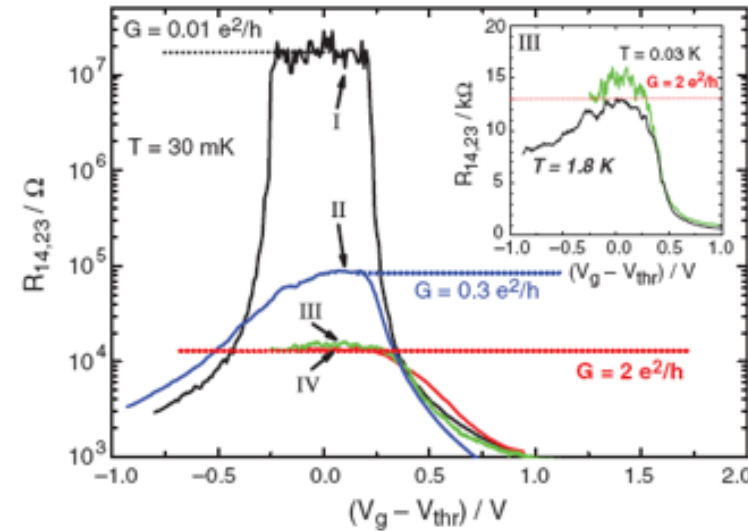
$$H = H_{\text{QSHE}} + H_{\text{virtual-lead}} + H_{\text{couple}}$$

H_{QSHE} : HgTe/CdTe QWs model



Normal dephasing

Spin dephasing



Experiments

- ❑ The longitudinal resistance of HgTe/CdTe QWs is insensitive to normal dephasing but sensitive to the spin dephasing.
- ❑ Numerical calculation is consistent with the experimental data.

H. Jiang, S.G. Cheng, Q.F. Sun, and X.C. Xie, PRL, 103, 036803 (2009).

H. Jiang, S.G. Cheng, Q.F. Sun, and X.C. Xie, Physics, 40, 454 (2011).

Conclusion on dephasing effect in 2D quantum Spin Hall insulators



- The spin dephasing plays important roles in QSHE, it makes the quantized longitudinal resistance only observable in mesoscopic systems. However, the spin accumulation measurement that is robust against any dephasing may provide a new playground.
- As far as helical edge state is not destroyed, the spin Hall resistance is quantized, independent of model or material detail. Therefore, it can better reflect the topological nature of QSHE. The spin Hall resistance can be measured by measurements of the polarization resistance.

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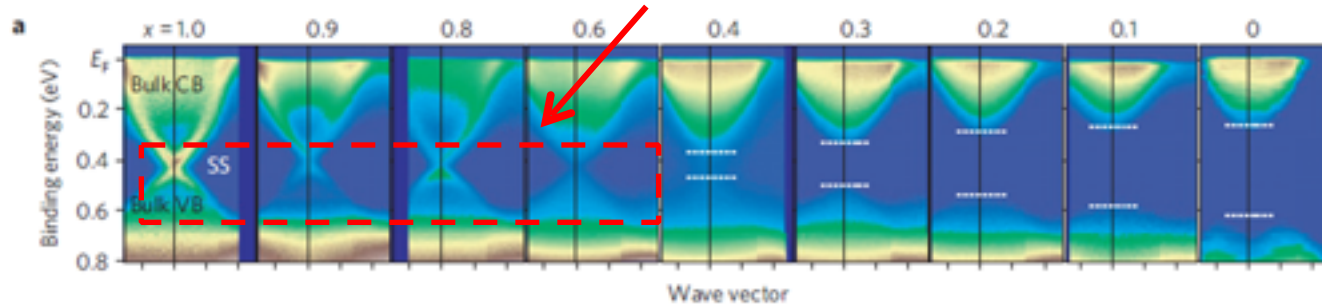
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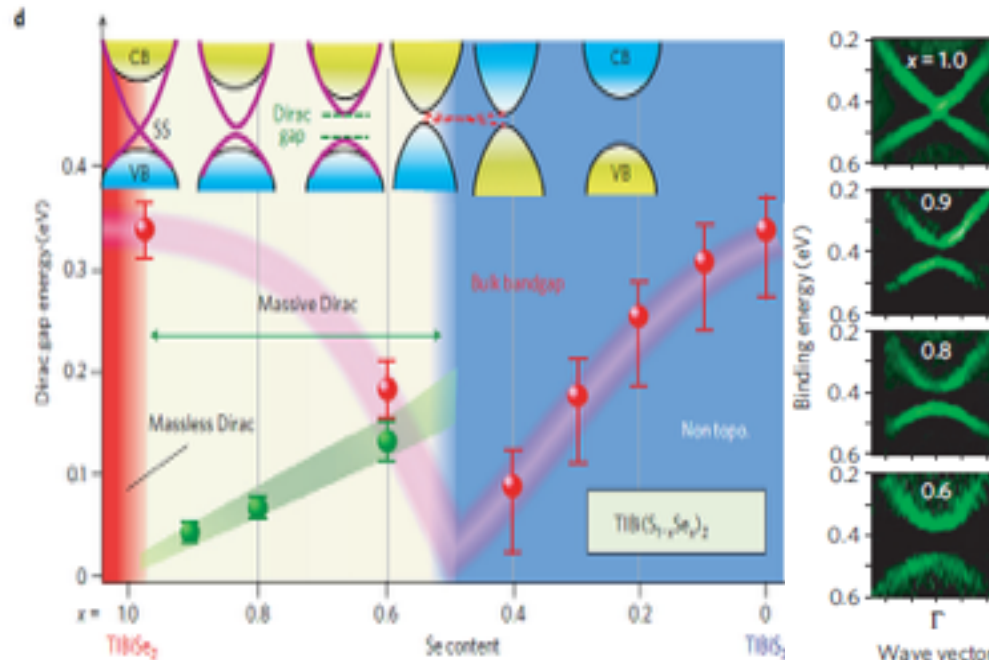
- ❑ Multiple Anderson transition in Weyl semimetals

Anomalous 'gap-like' features in $\text{TlBi}(\text{S}_{1-x}\text{Se}_x)_2$ surface states

Anomalous 'gap-like' features around the Dirac point



- TQPT in a tuneable spin-orbital system.
- The TQPT occurs at critical point $\delta = 0.5$.



- The surface states acquire 'gap-like' feature before the TQPT point.
- The surface state preserves the TRS.
- The typical gap is 50 meV for $x=0.9$.

Anomalous 'gap-like' features in $\text{TlBi}(\text{S}_{1-x}\text{Se}_x)_2$ surface states

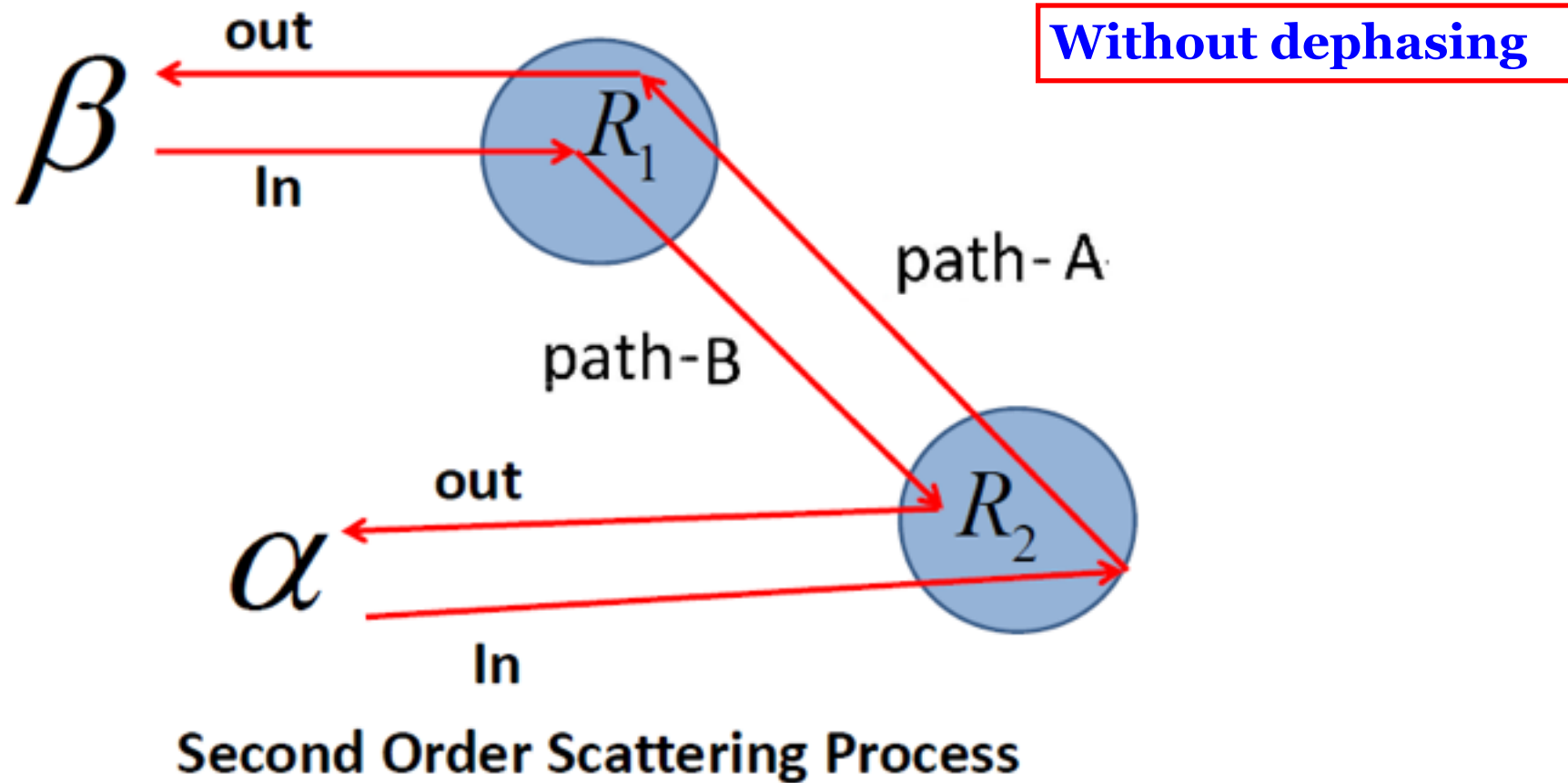


What mechanism leads to the anomalous 'gap-like' feature in helical surface states?

- ❑ in the strong 3D topological insulator
- ❑ preserve the spin-momentum locking (helical) property
- ❑ no magnetic impurity, thus no spin dephasing
- ❑ large sample thickness, thus no finite size effect

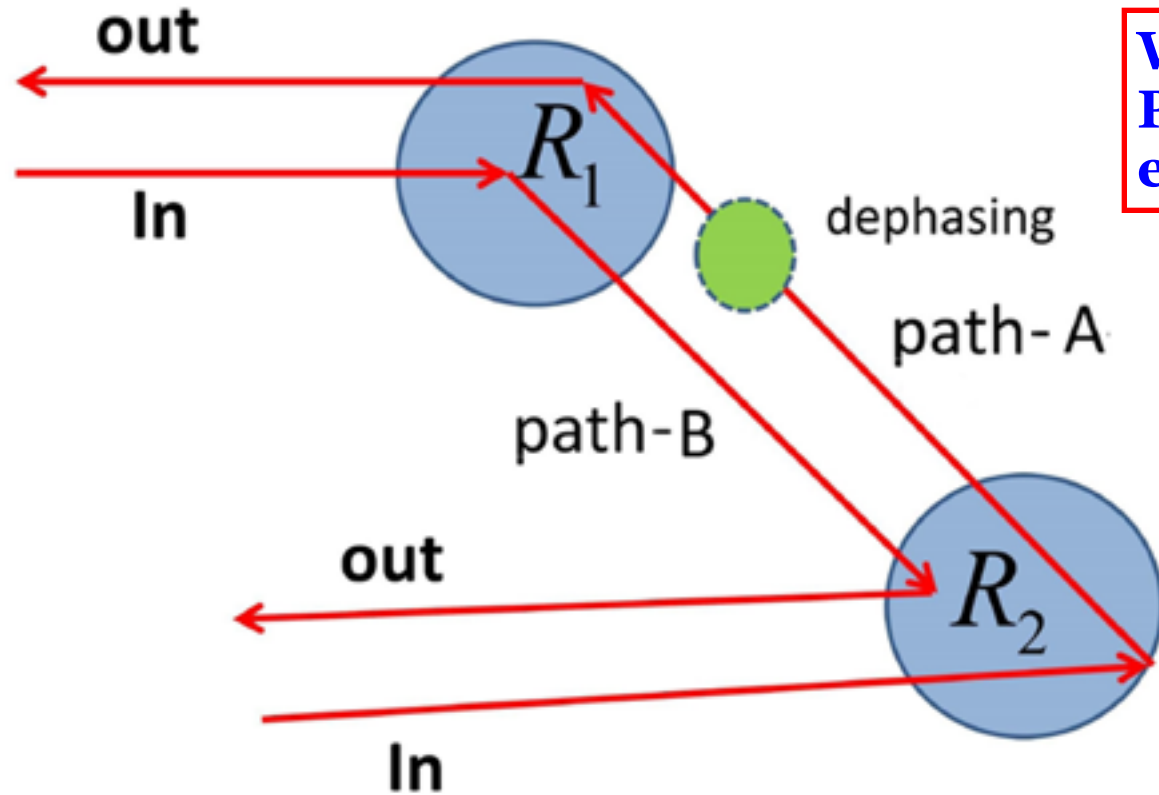
Re-examine the normal dephasing effect.

The role of dephasing effect on backscattering



The π Berry phase between A-path and B-path eliminates the backscattering.

The role of dephasing effect on backscattering



**With normal dephasing:
Phase uncertainty due to
e-e and e-ph interactions**

Second Order Scattering Process

The phase uncertainty between A-path and B-path leads to backscattering.

Scattering process of helical surface states

Surface states Hamiltonian:

$$H(\mathbf{k}) = s\hbar v_f (\hat{\mathbf{z}} \times \mathbf{k}) \cdot \boldsymbol{\sigma}$$

The scattered wave function:

$$\psi = \varphi_{\vec{k}_{in}}(\vec{r}) + \frac{f(\theta_{in}, \theta_{out})}{\sqrt{r}} \begin{pmatrix} 1 & e^{i\theta_{out}} \end{pmatrix}^T e^{ikr}$$

The scattering amplitude:

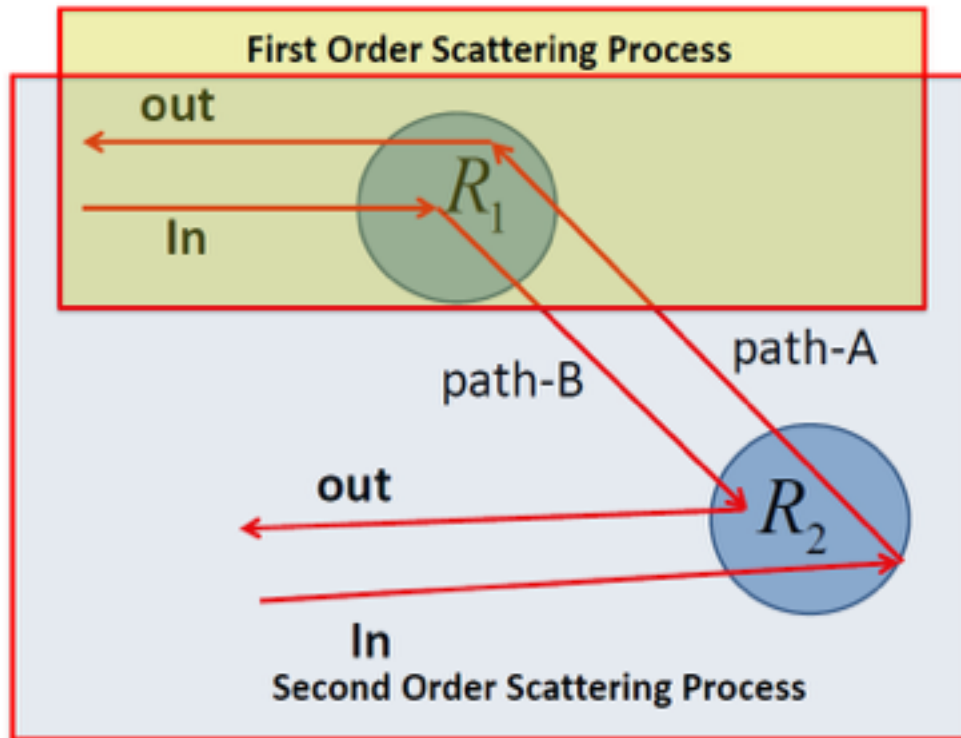
$$f(\theta_{in}, \theta_{out})$$

The scattering cross section:

$$\sigma(\theta_{in}, \theta_{out}) = |f(\theta_{in}, \theta_{out})|^2$$

The scattering process is determined by the scattering cross section $\sigma(\theta_{in}, \theta_{out})$

The backscattering amplitude: without dephasing



The scattering amplitude:

First order:

$$f_1(\theta_{in}, \theta_{out}) = \frac{1}{v_f} \sqrt{\frac{2k}{-i\pi}} \left(1 + e^{-i(\theta_{out} - \theta_{in})}\right) \Gamma$$

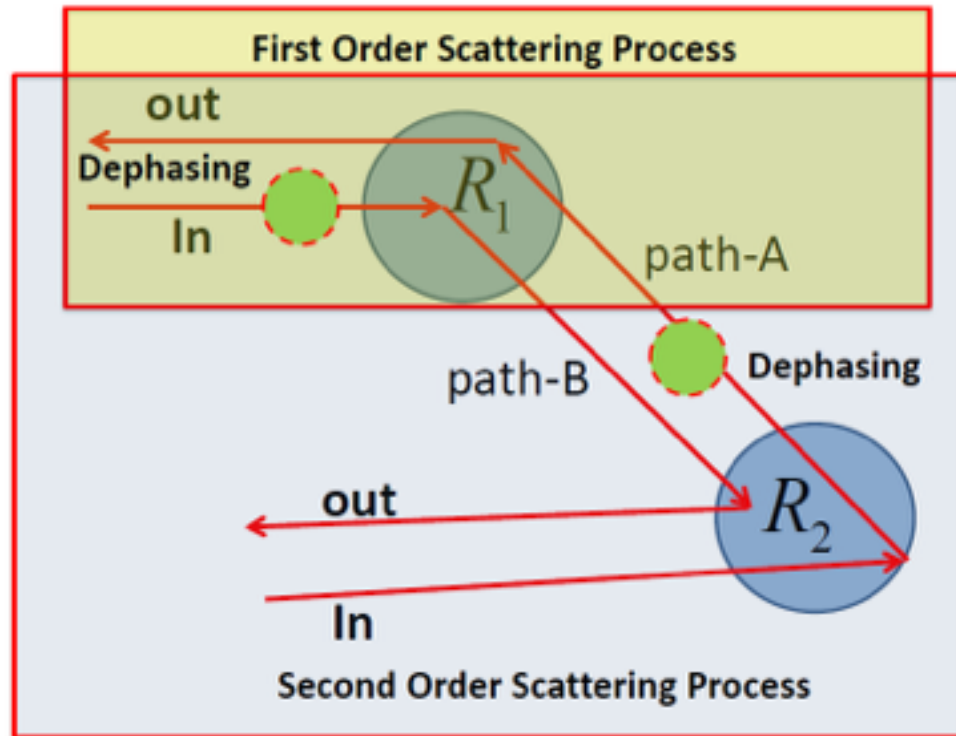
Second order:

$$f_2(\theta_{in}, \theta_{out}) = \frac{4k \left(1 + e^{-i(\theta_{out} - \theta_{in})}\right)}{-i\pi v_f^2 \sqrt{|\mathbf{R}_2 - \mathbf{R}_1|}} \Gamma^2$$

□. No Backscattering without dephasing because of destructive interference between A-path and B-path.

The backscattering amplitude: with normal dephasing

The backscattering cross-section:



First order:

$$\sigma_1(\theta_{out}=\pi+\theta_{in}, \theta_{in}) = 0$$

Second order:

$$\sigma(\pi+\theta_{in}, \theta_{in}) = \frac{8k^2\Gamma^4 \langle \delta\varphi^2 \rangle}{\pi^2 v_f^4 |R_2 - R_1|}$$

Phase uncertainty: $\langle \delta\varphi^2 \rangle$

Scatter strength: Γ

Impurity distance: $|R_2 - R_1|$

□. Normal dephasing causes backscattering at the second order process, while the first order backscattering cross section remains zero.

Backscattering cross-section: Anderson impurity and charge impurity

Anderson impurity:

$$U_S (\mathbf{r} - \mathbf{R}_i) = U_0 \delta (\mathbf{r} - \mathbf{R}_i)$$

Backscattering cross-section:

$$\sigma_S (\pi + \theta_{in}, \theta_{in}) = \frac{8k^2 U_0^4 \langle \delta \varphi^2 \rangle}{\pi^2 v_f^4 |\mathbf{R}_2 - \mathbf{R}_1|} \propto k^2 \quad \text{Dominant at high energy}$$

Charge impurity:

$$U_L (\mathbf{r} - \mathbf{R}_i) = \frac{\hbar v_f \Delta}{|\mathbf{r} - \mathbf{R}_i|}$$

Backscattering cross-section:

Dominant at low energy

$$\sigma_L (\pi + \theta_{in}, \theta_{in}) = \frac{8\Delta^4 \langle \delta \varphi^2 \rangle}{\pi^2 k^2 |\mathbf{R}_2 - \mathbf{R}_1|} \propto 1/k^2$$

□ **Combination of dephasing and charge impurity cause extremely large backscattering around the Dirac point.**

Combined effect of dephasing and charge impurity scattering

Band broadening effect of surface quasi-particle:

$$-2 \operatorname{Im} \sum^R(k, \omega) = \frac{\hbar}{\tau} = \hbar v_f n_i \sigma_T$$

The imaginary part of quasi-particle self energy:

$$-\operatorname{Im} \Sigma^R(k, \epsilon_k) = \frac{2n_i \xi^2}{\epsilon_k} + \frac{4n_i \xi^4}{\hbar \pi v_f^2 \tau_\varphi \epsilon_k^2}$$

Total transport cross section:

$$\sigma_T$$

Charge impurity concentration:

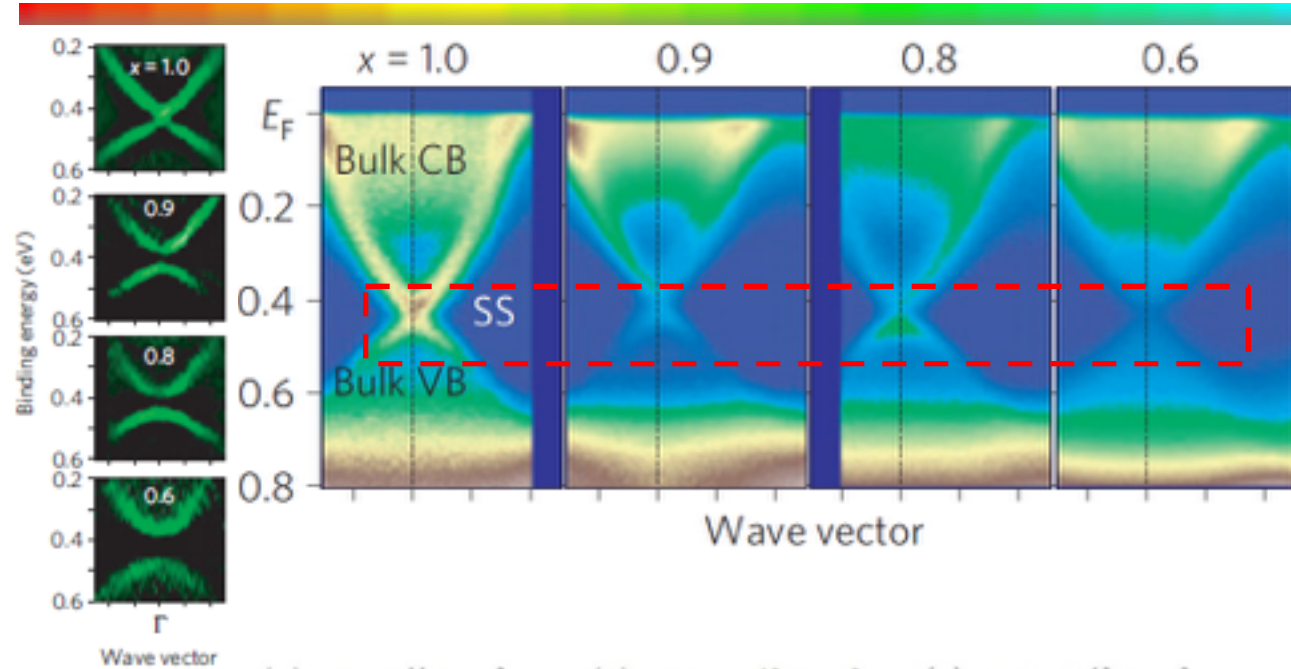
$$n_i$$

Dephasing time:

$$\tau_\varphi \simeq 10^{-10} \text{ s}$$

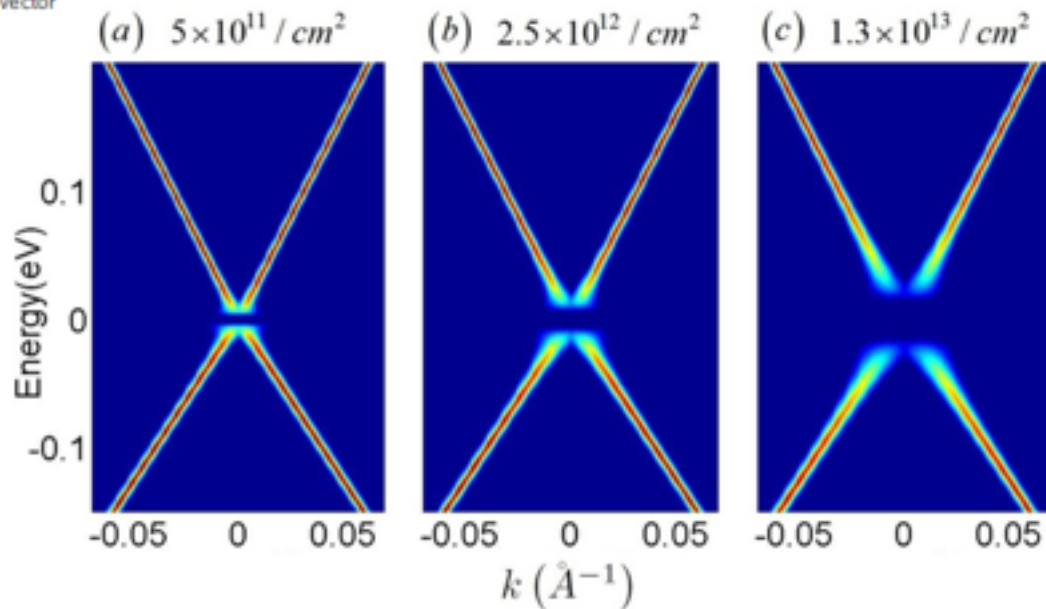
Temperature dependent

Comparison with experimental results



Experiment:
T. Sato, et al., Nature
Physics 7, 840 (2011).

The large ratio of S substitution for Se (>10%) may lead to substantial crystal vacancies, and these vacancies play the role of charge impurity.



Simulation:
Bandwidth broadening effect.

Conclusion on dephasing effect in 3D TIs

➤ 3D TIs surface states:

- ❑ The combined effect of normal dephasing and impurity scattering can cause backscattering in the helical SS.
- ❑ Normal dephasing and charge impurity cause large backscattering around the Dirac point, and leads to the anomalous 'gap-like' features found in recent experiments.

Outline



➤ Introduction

- ❑ From quantum Hall systems to topological insulators

➤ Dephasing effects in topological insulators

- ❑ Edge states of 2D quantum spin Hall insulators

- ❑ Surface states of 3D topological insulators

➤ Disorder effects in topological insulators

- ❑ Tunable Anderson transition in 2D quantum spin Hall insulators

- ❑ Multiple Anderson transition in Weyl semimetals

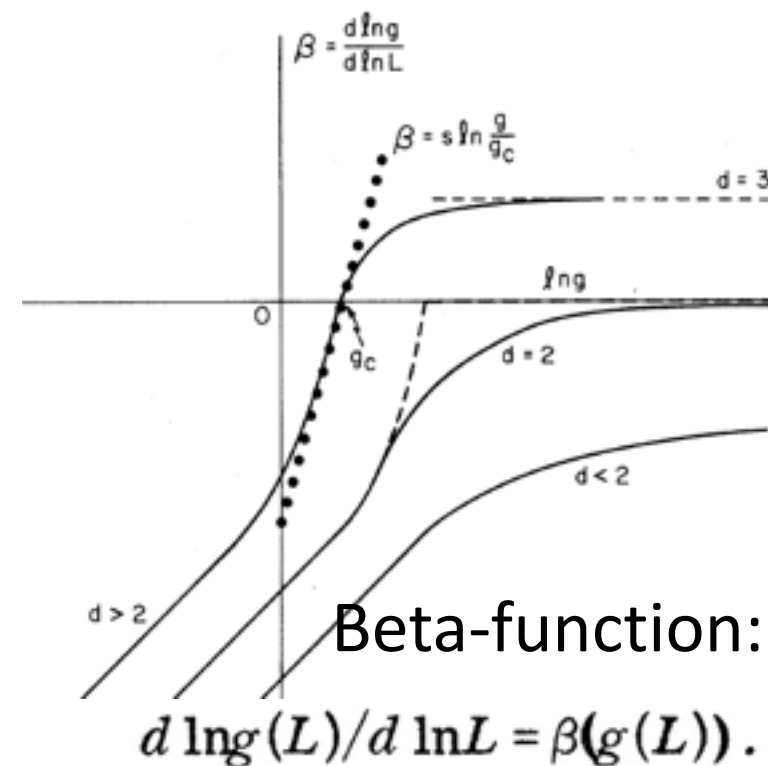
Background of Localization

All the states are **localized** in **1D** and **2D** without:
(i) **magnetic field**; (ii) **SOC**; (iii) **electron-electron interaction**

Anderson transition in **2D** and symmetry class

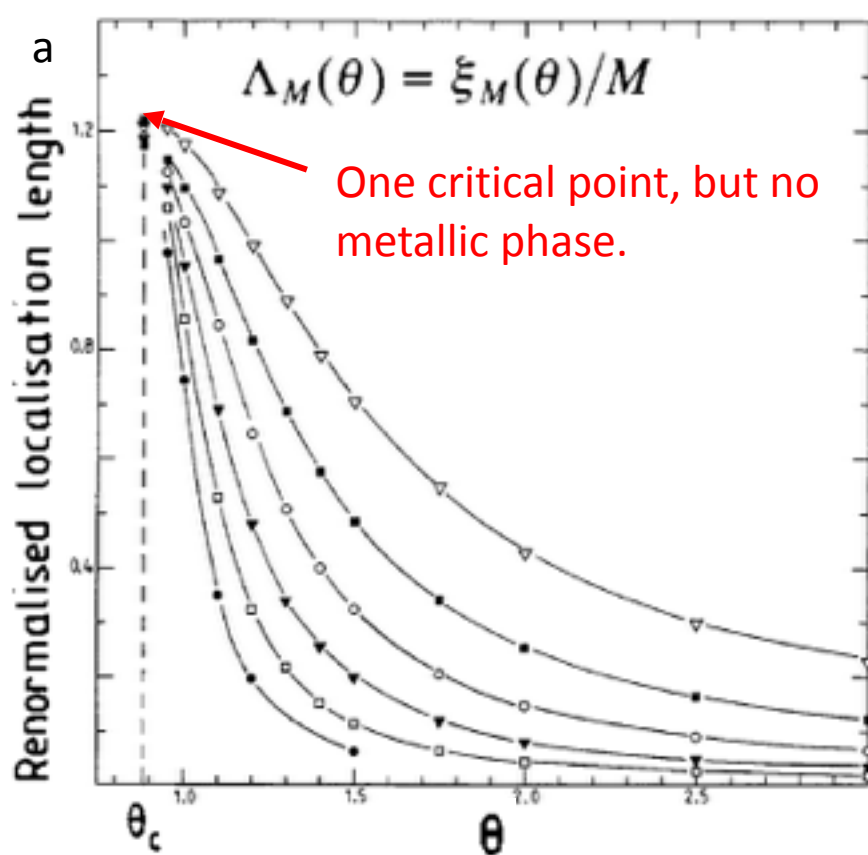
- **Orthogonal** : TRS and spin rotation symmetry
 - all the states **localized**
- **Unitary** : break TRS Possible Metallic Phase?
 - e.g. QHE and QAH, **critical point**
- **symplectic** : TRS without spin rotation symmetry
 - **SOC**, **metallic phase**

E. Abrahams, et al, PRL. 42, 673 (1979).



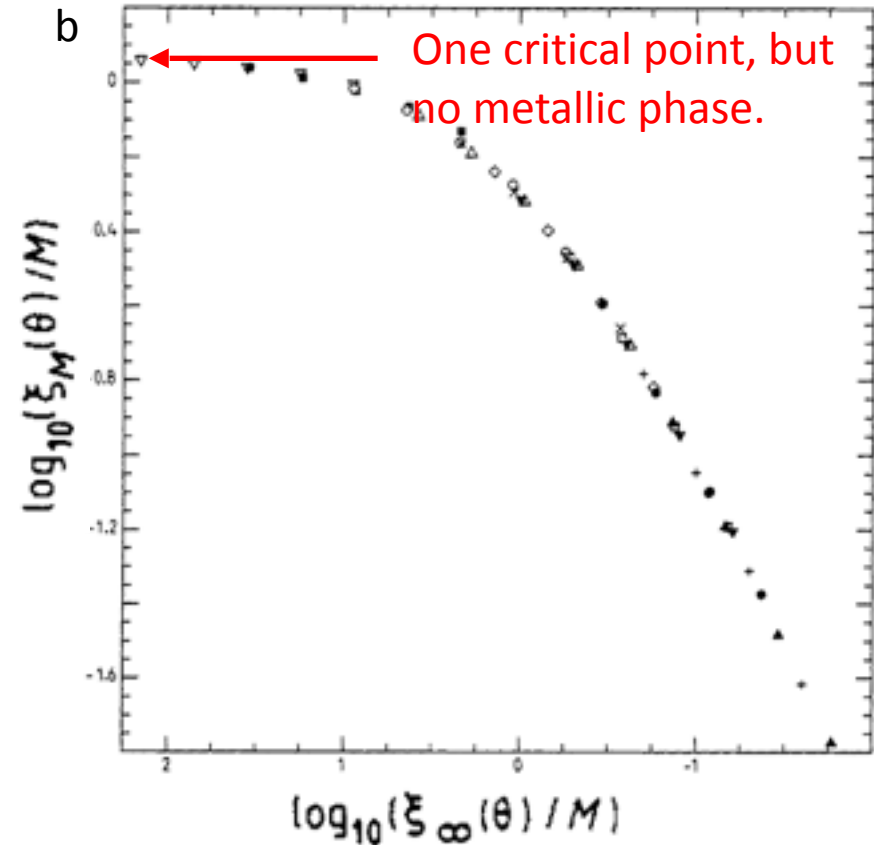
A. Huckestein, RMP. 67, 357 (1995).
F. Evers et al., RMP, 80, 1355 (2008)

Scaling in IQHE (Unitary class): critical point but no metallic phase.



System widths

$M = 4 (\nabla)$
 $M = 8 (\blacksquare)$
 $M = 16 (\bigcirc)$
 $M = 32 (\blacktriangledown)$
 $M = 64 (\square)$
 $M = 128 (\bullet)$



■ The renormalized localization length of integer quantum Hall effect as a function of energy. The vertical break line marks the Landau level centre.

■ The one parameter scaling of the renormalized localization length in integer quantum Hall effect.

JT Chalker and PD Coddington J. Phys. C. 21, 2665 (1988).

Tunable Anderson transition (AT) in QSH insulator

Spin-up BHZ Hamiltonian (unitary)

$$H_0(k) = A(k_x\tau_x + k_y\tau_y) + (M - Bk^2)\tau_z + V_{dis}\tau_0$$

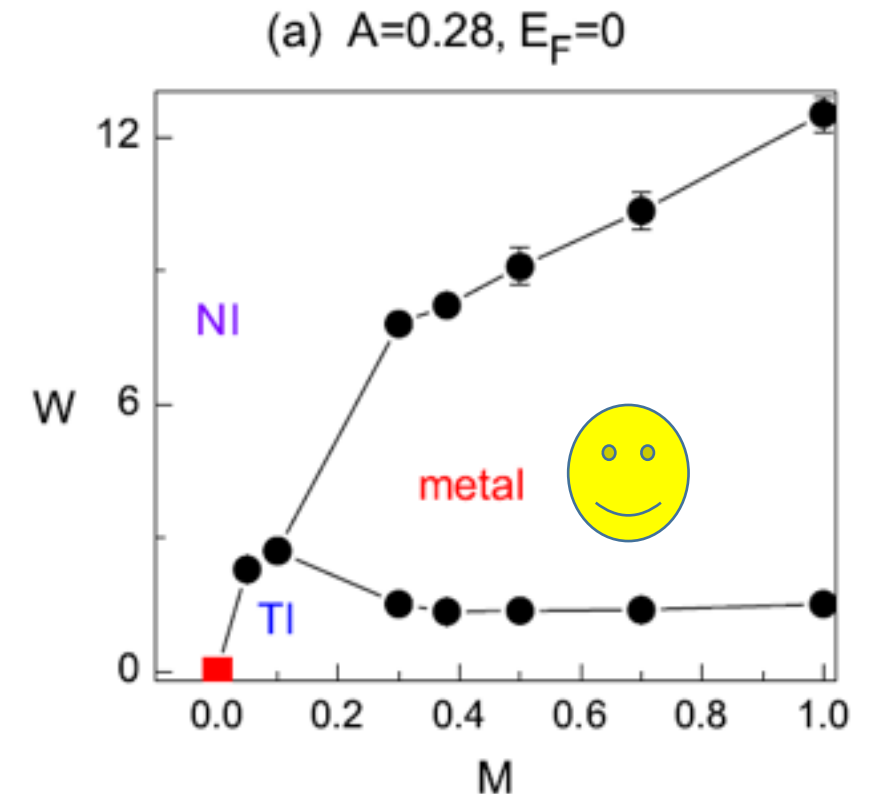
□ Tunable parameters

- topological mass M
- Electron-hole hybrid strength A
- Fermi energy E_F

□ **Metallic phase** in 2D unitary class

□ Anderson transitions are dependent on the parameter M

□ **TI-Metallic-NI** at large M



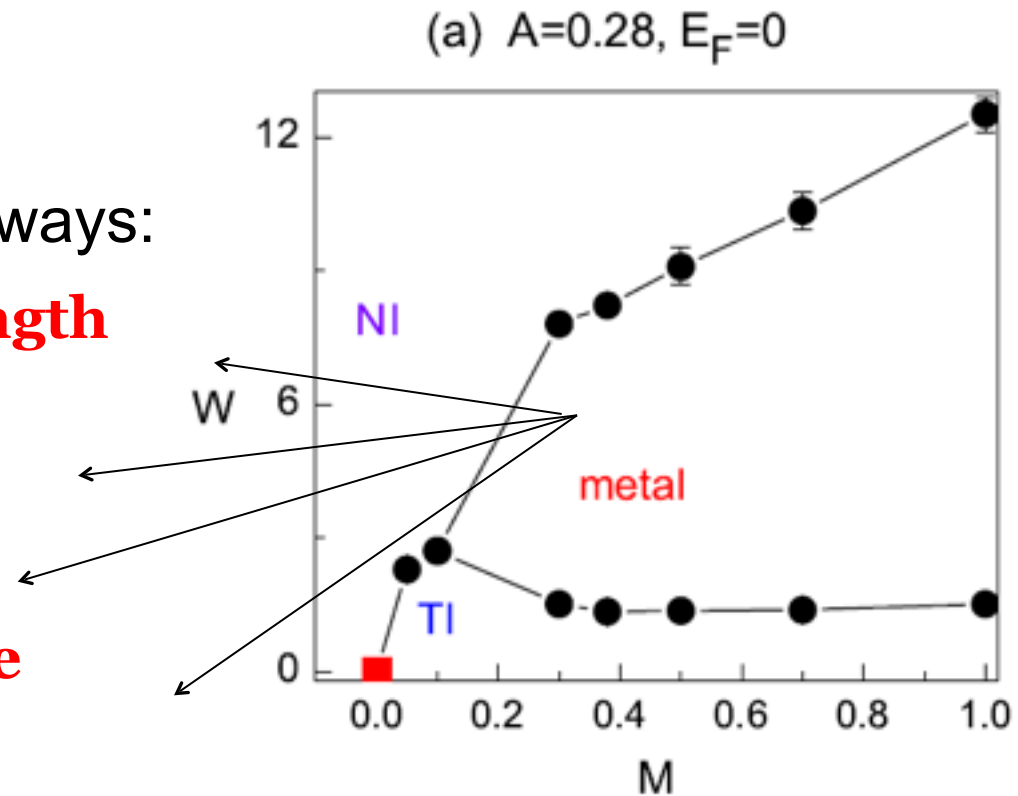
Tunable Anderson transition (AT) in QSH insulator

Spin-up BHZ Hamiltonian (unitary)

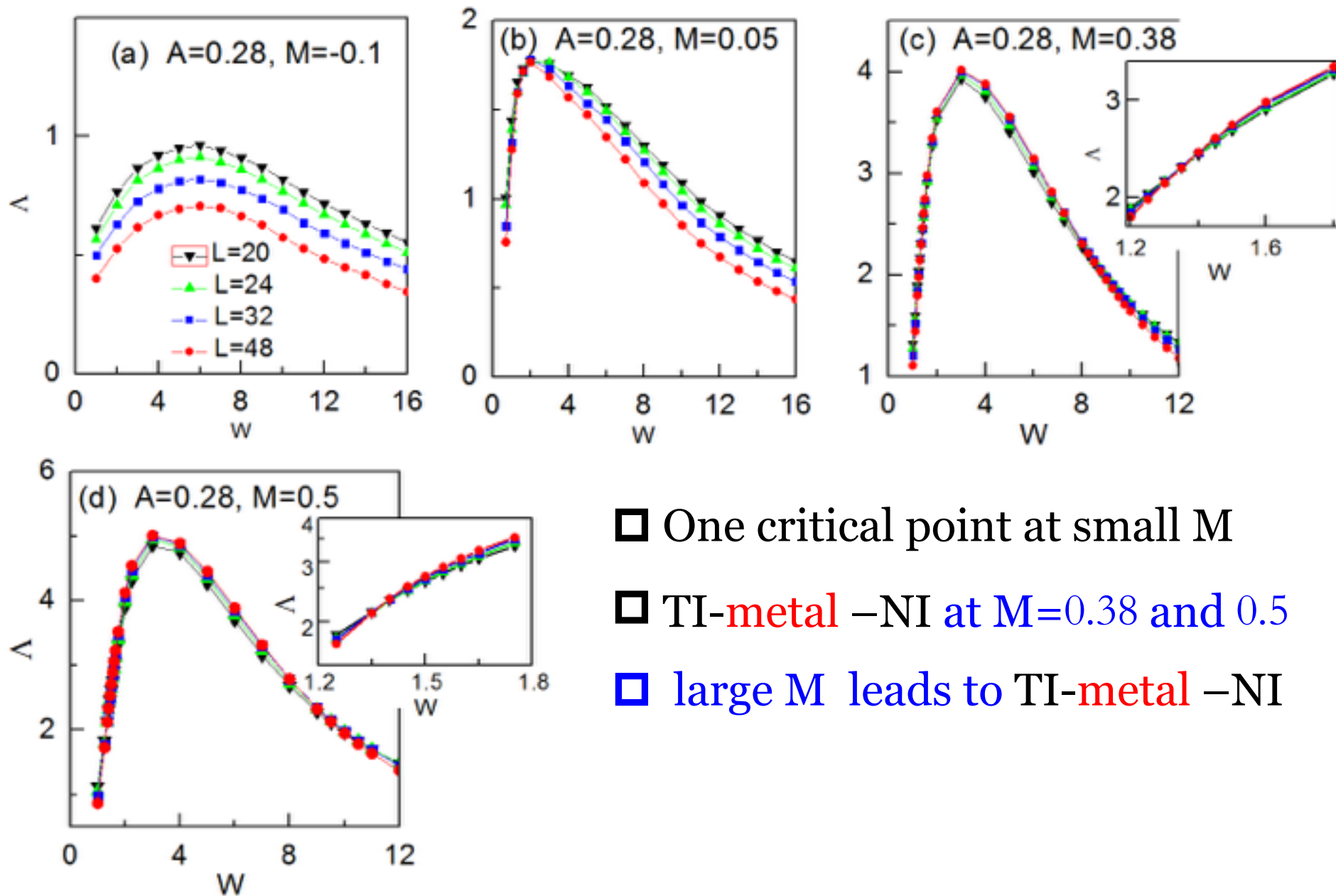
$$H_0(k) = A(k_x\tau_x + k_y\tau_y) + (M - Bk^2)\tau_z + V_{dis}\tau_0$$

Investigations in four possible ways:

- ❑ (I) Scaling localization length
- ❑ (II) Energy level statistics
- ❑ (III) Participation ratio
- ❑ (IV) Intrinsic conductance

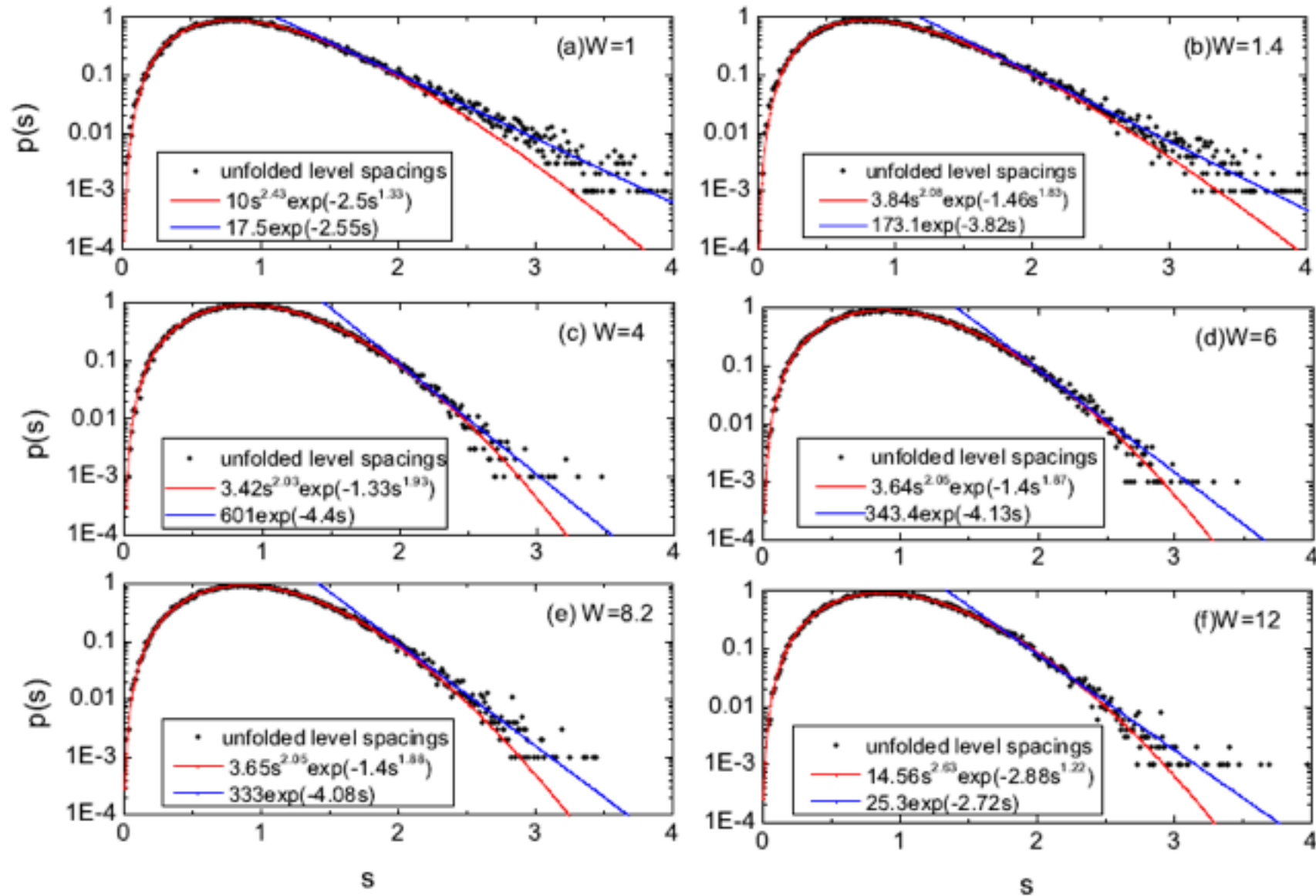


(I) Localization length scaling at different masses M



- One critical point at small M
- TI-metal – NI at $M=0.38$ and 0.5
- large M leads to TI-metal – NI

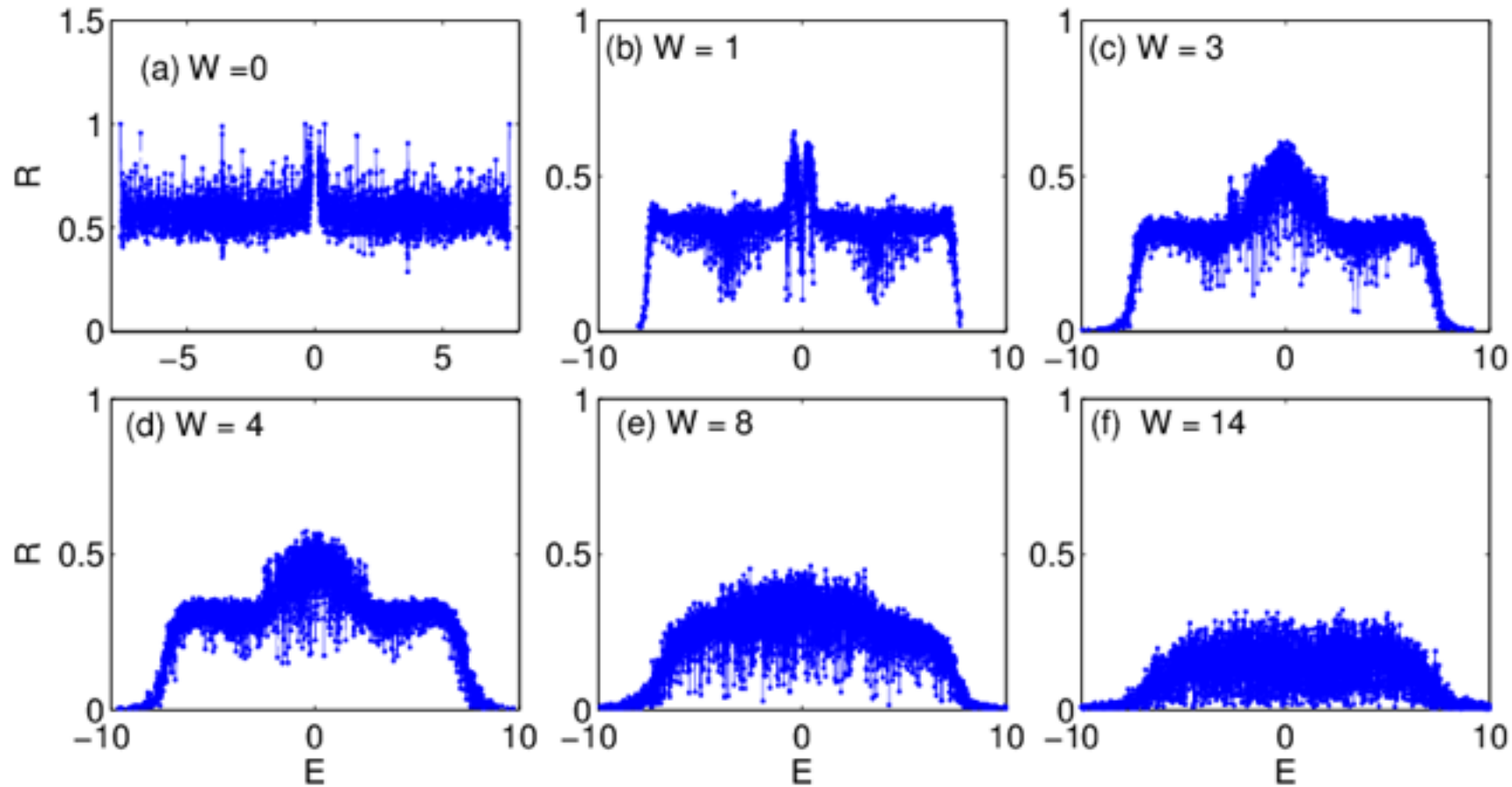
(II) Energy level statistics (ELS) at $A=0.28$, $M=0.38$ and $E_F=0$



□ Supporting the existence of extended states

(III) Participation ratio (PR)

$$\text{PR: } R = \sum_{i=1}^N |a_i|^4 / (N \sum_{i=1}^N |a_i|^2)^2$$



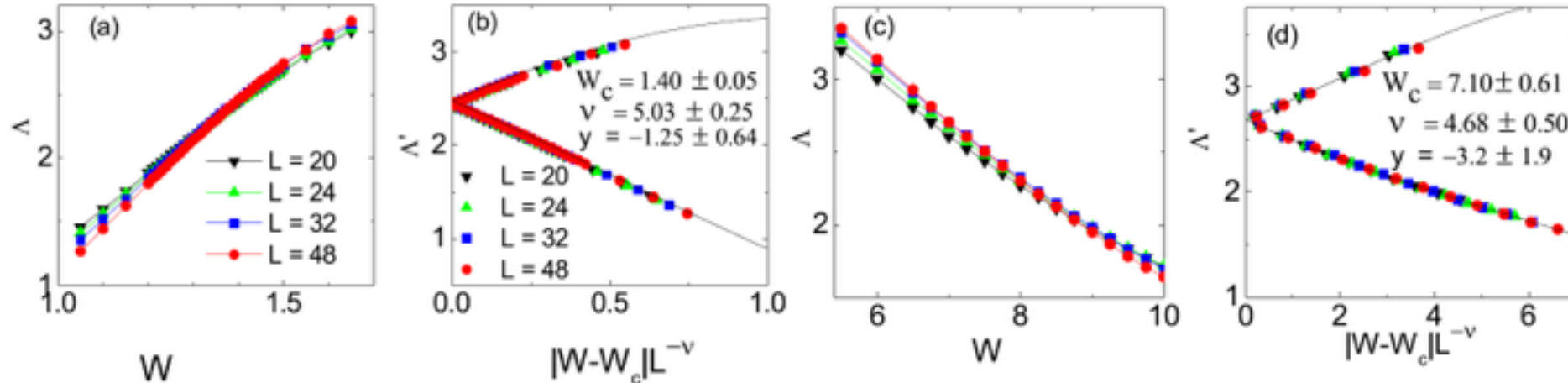
❑ The extended states come into the gap with increasing disorder strength.

□ One parameter scaling behaviour

$$\Lambda(W, L) = \Lambda_c + \sum_{n=1}^4 a_n (\bar{W} - \bar{W}_c)^n L^{-n/\nu} + b_0 L^y$$

$$\Lambda'(W, L) = \Lambda(W, L) - b_0 L^y$$

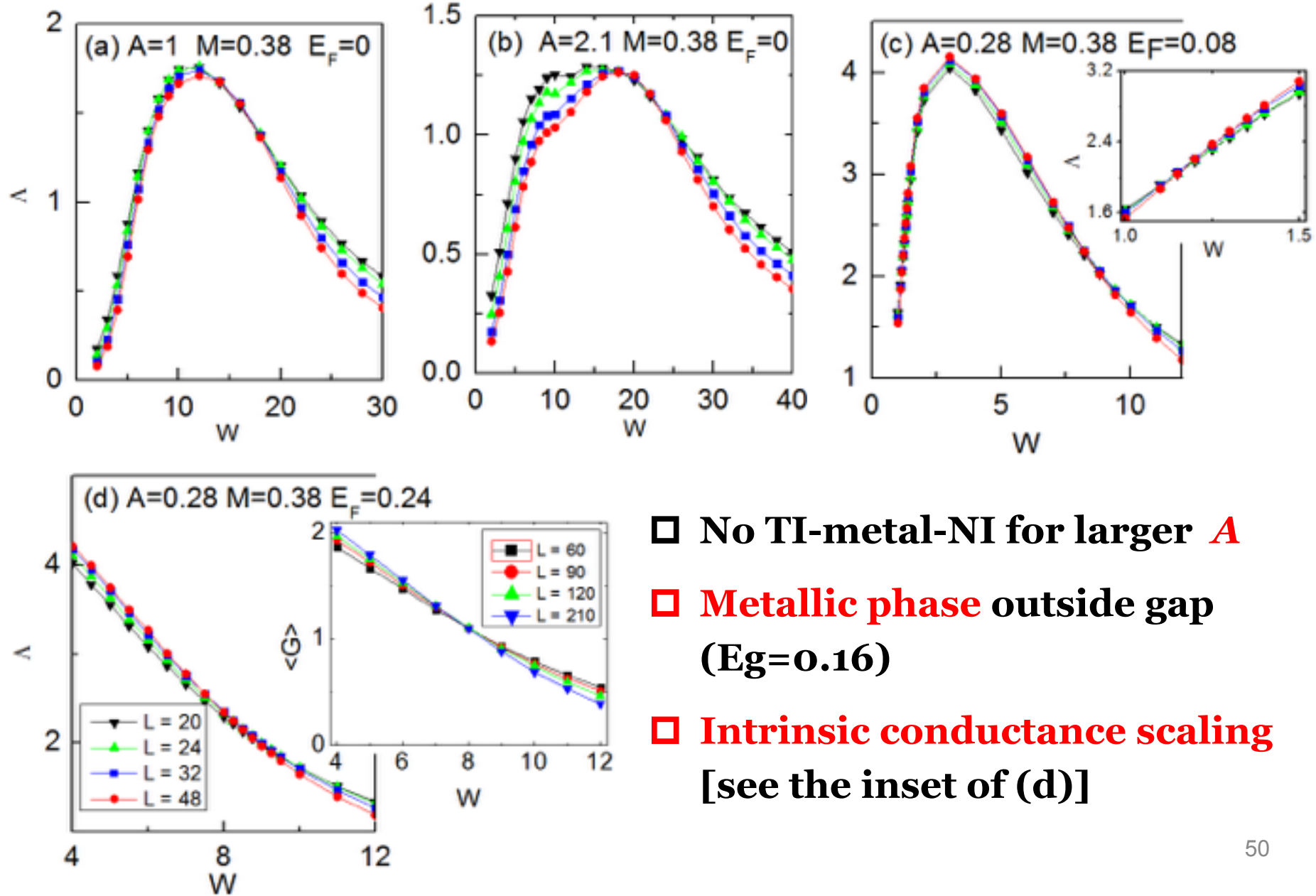
$$A=0.28, M=0.38, E_F=0$$



$$\chi^2 = \sum_{n=1}^N (\Lambda_n - \Lambda(W_n, L_n))^2 / \sigma_n^2$$

χ^2/N is 3.3 and 3.5 for (b) and (d) respectively.

AT with different electron-hole hybrid strength and Fermi energy

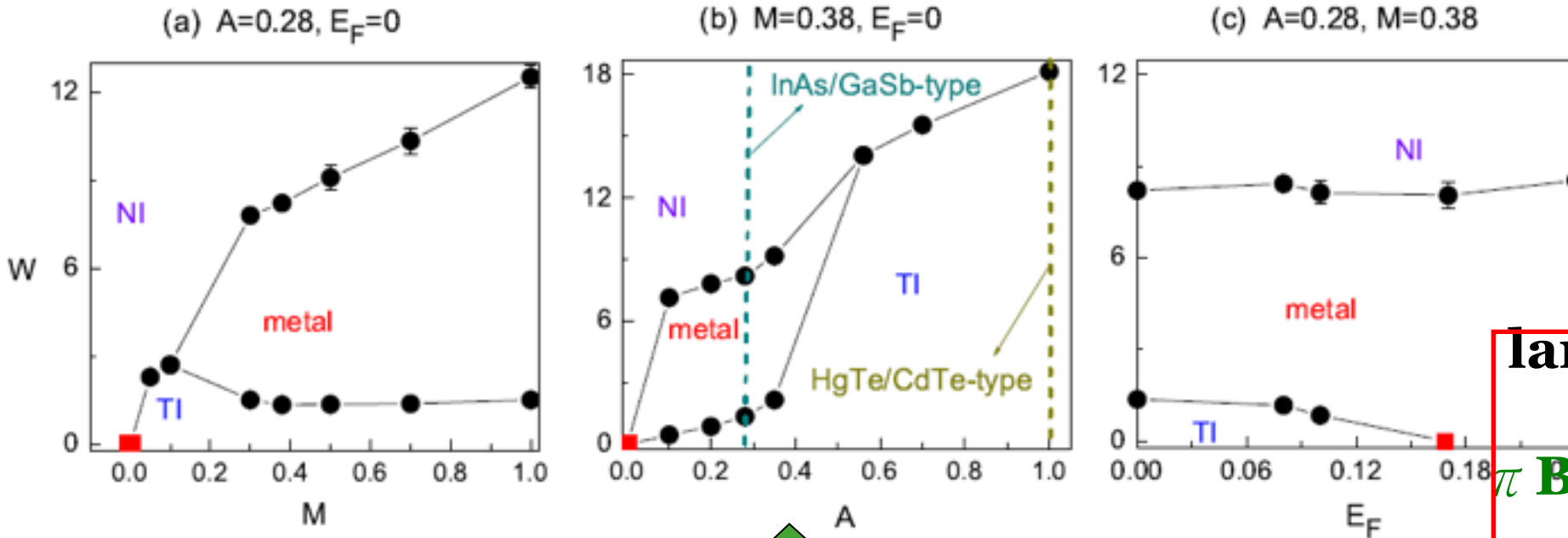


□ No TI-metal-NI for larger A

□ **Metallic phase** outside gap
($E_g=0.16$)

□ **Intrinsic conductance scaling**
[see the inset of (d)]

Phase diagrams



□ Berry phase

$$\gamma(E_F) = \left(1 - \frac{(M - Bk_F^2)}{\sqrt{A^2k_F^2 + (M - Bk_F^2)^2}}\right)\pi.$$

➤ When $\gamma \rightarrow (0 \rightarrow \pi \rightarrow 2\pi)$, weak localization (WL)→WAL→WL

◆ **Beta-function is positive for WAL in 2D**

■ InAs/GaSb-type, $M/B \gg A^2/B^2$, $\gamma(E_g) \approx \pi \rightarrow$ WAL

■ HgTe/CdTe-type, $M/B < A^2/B^2$, $\gamma(E_g) = 0 \rightarrow$ WL

large **M** and small **A**

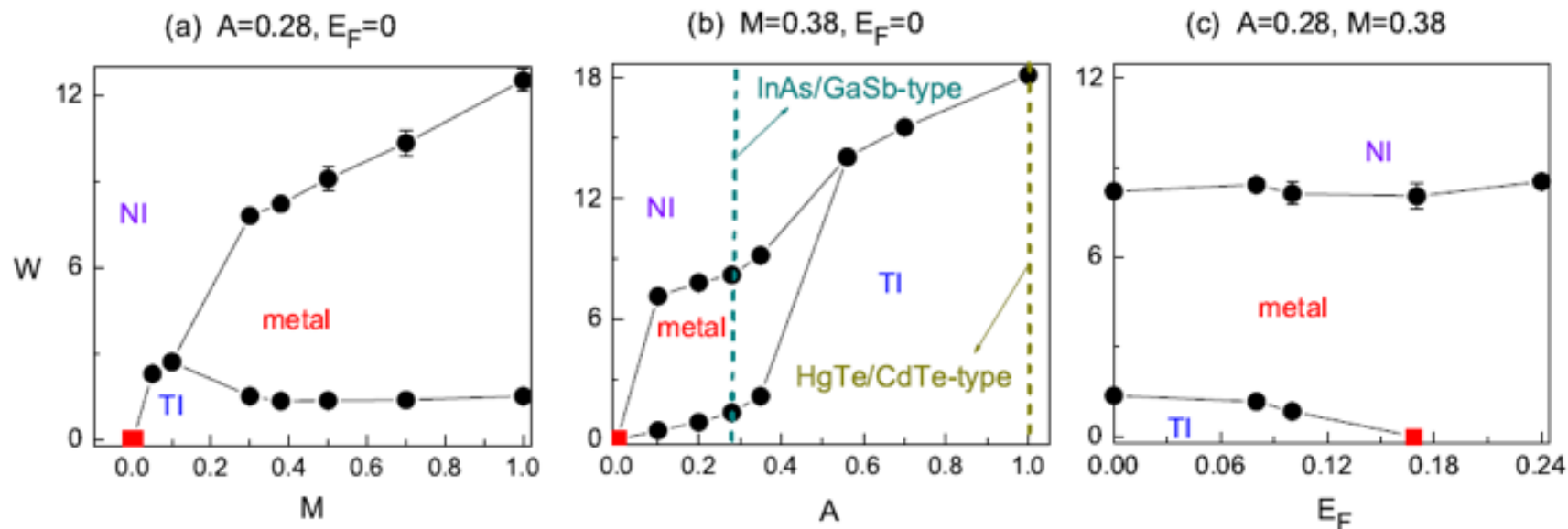
π Berry phase or WAL

$$\beta = \frac{d \ln g}{d \ln L} = d - 2 - \frac{c}{g} > 0$$

TI-Metal-NI

Conclusion on Tunable Anderson transition in QSH insulator

- Anderson transition is **tunable by model** parameters in the BHZ model.
- We find **a possible metallic phase** in 2D unitary class.
 - **localization length scaling, the conductance scaling, energy level statistics and participation ratio.**
- Our results are interpreted by the **Berry phase or WAL.**



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➤ Disorder effects in topological insulators

- ❑ Tunable Anderson transition in 2D quantum spin Hall insulators

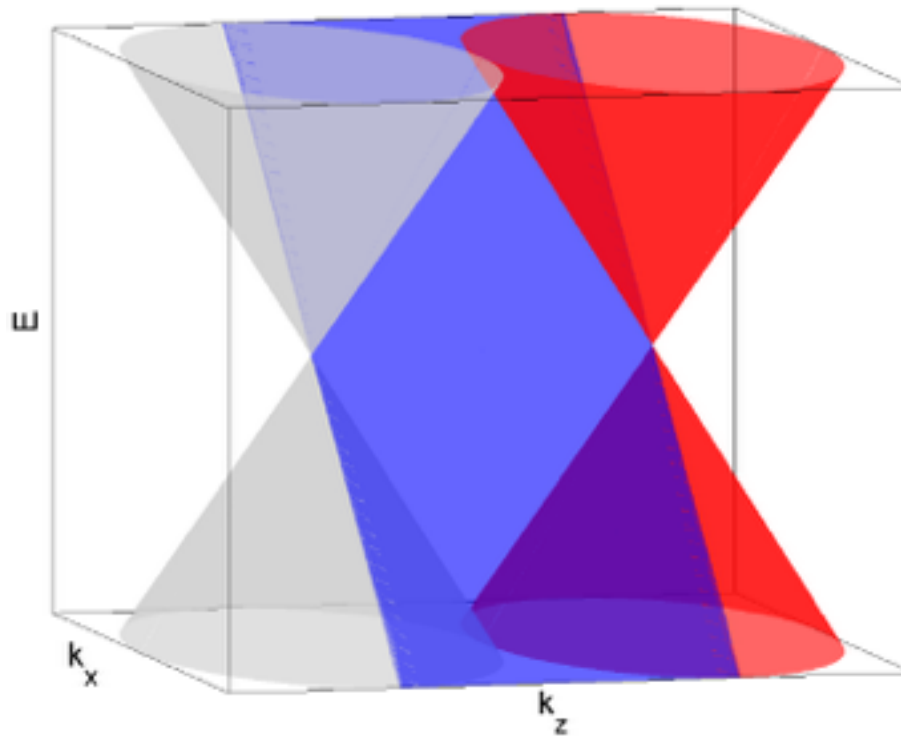
- ❑ Multiple Anderson transition in Weyl semimetals

Hamiltonian and power spectrums

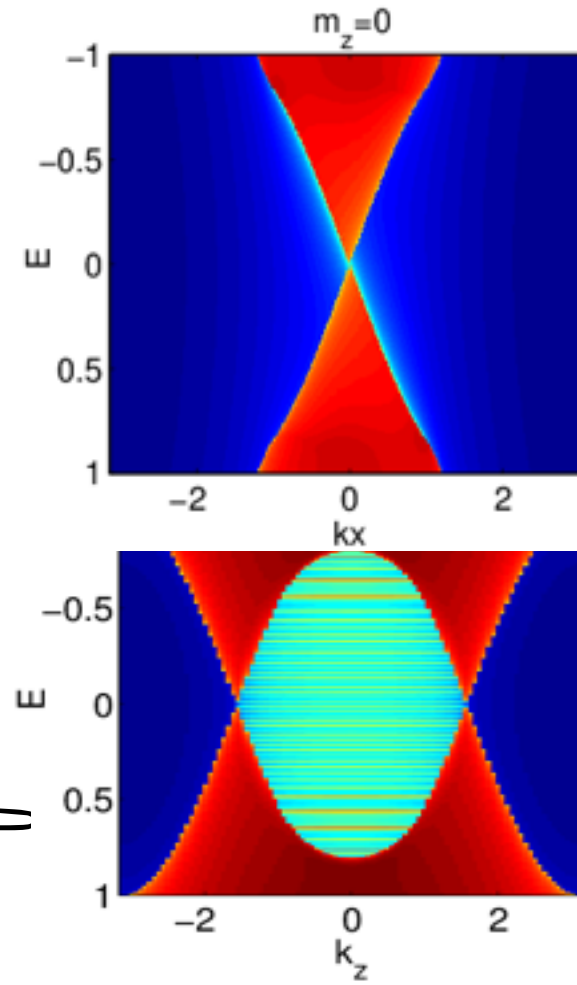
□ Hamiltonian

$$H_0 = M_k \sigma_z + t_x \sin k_x \sigma_x + t_y \sin k_y \sigma_y$$

where $M_k = m_z - t_z \cos k_z + m_0(2 - \cos k_x - \cos k_y)$



parameters: $t_x = t_y = t_z = 1$,
 $m_0 = 2.1$, $m_z = 0$

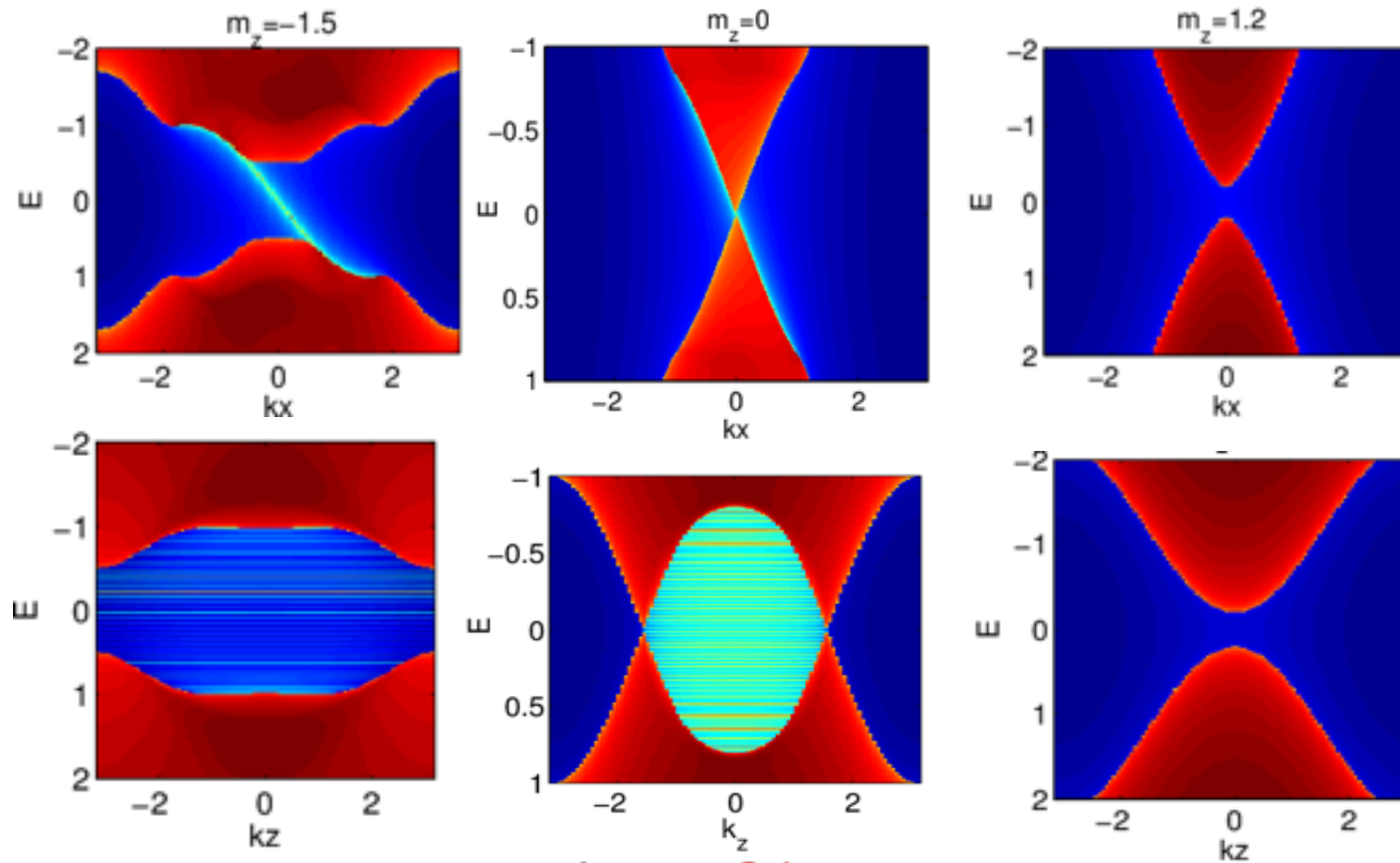


Hamiltonian and power spectrums (cont'd)

□ Hamiltonian

$$H_0 = M_k \sigma_z + t_x \sin k_x \sigma_x + t_y \sin k_y \sigma_y$$

where $M_k = m_z - t_z \cos k_z + m_0(2 - \cos k_x - \cos k_y)$



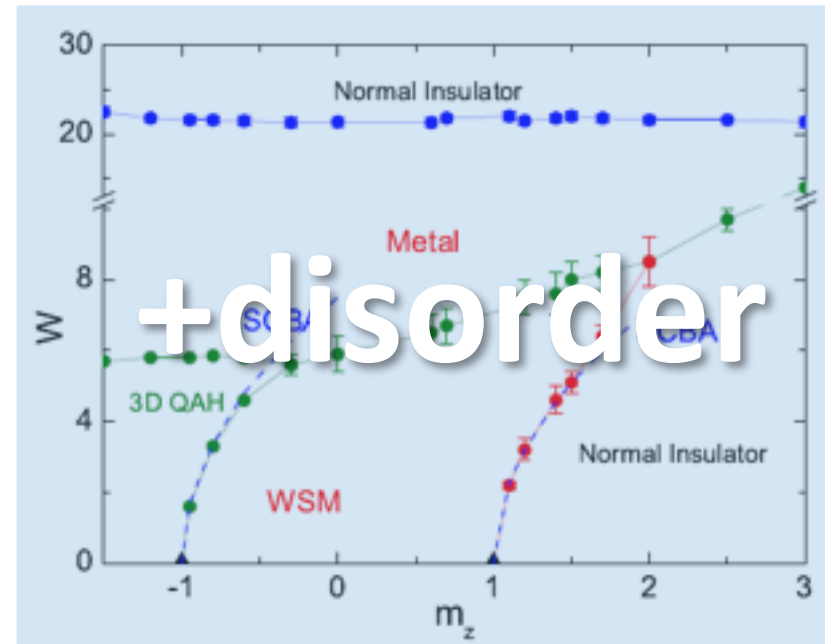
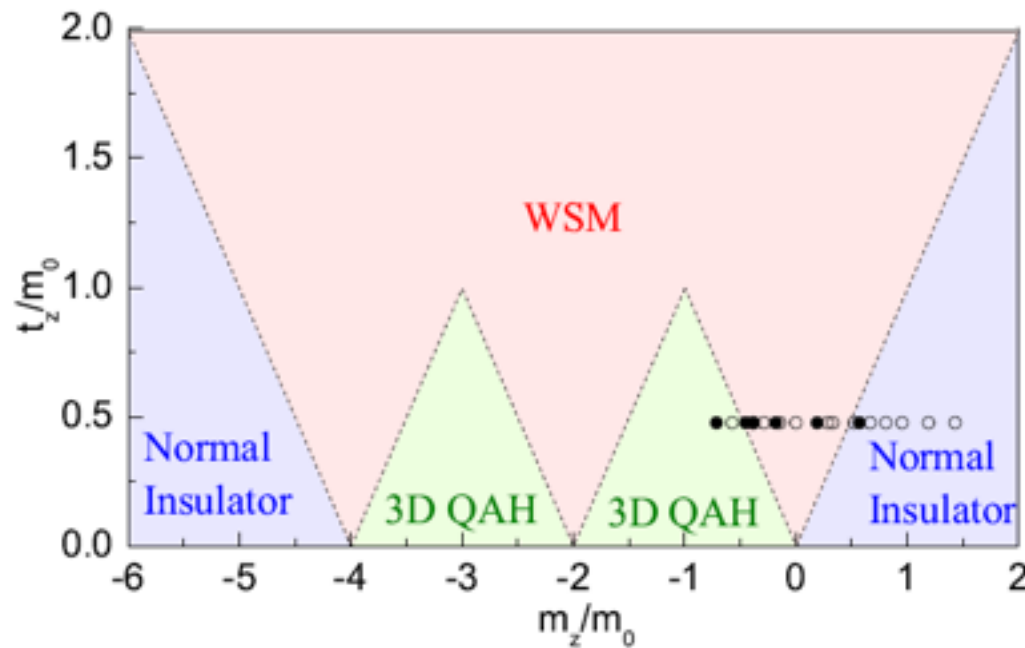
parameters: $t_x = t_y = t_z = 1$, $m_0 = 2.1$, $m_z = -1.5 \sim 1.2$

Phase diagram in clean limit + disorder

□ Clean Hamiltonian and phase diagram

$$H_0 = M_k \sigma_z + t_x \sin k_x \sigma_x + t_y \sin k_y \sigma_y$$

where $M_k = m_z - t_z \cos k_z + m_0(2 - \cos k_x - \cos k_y)$



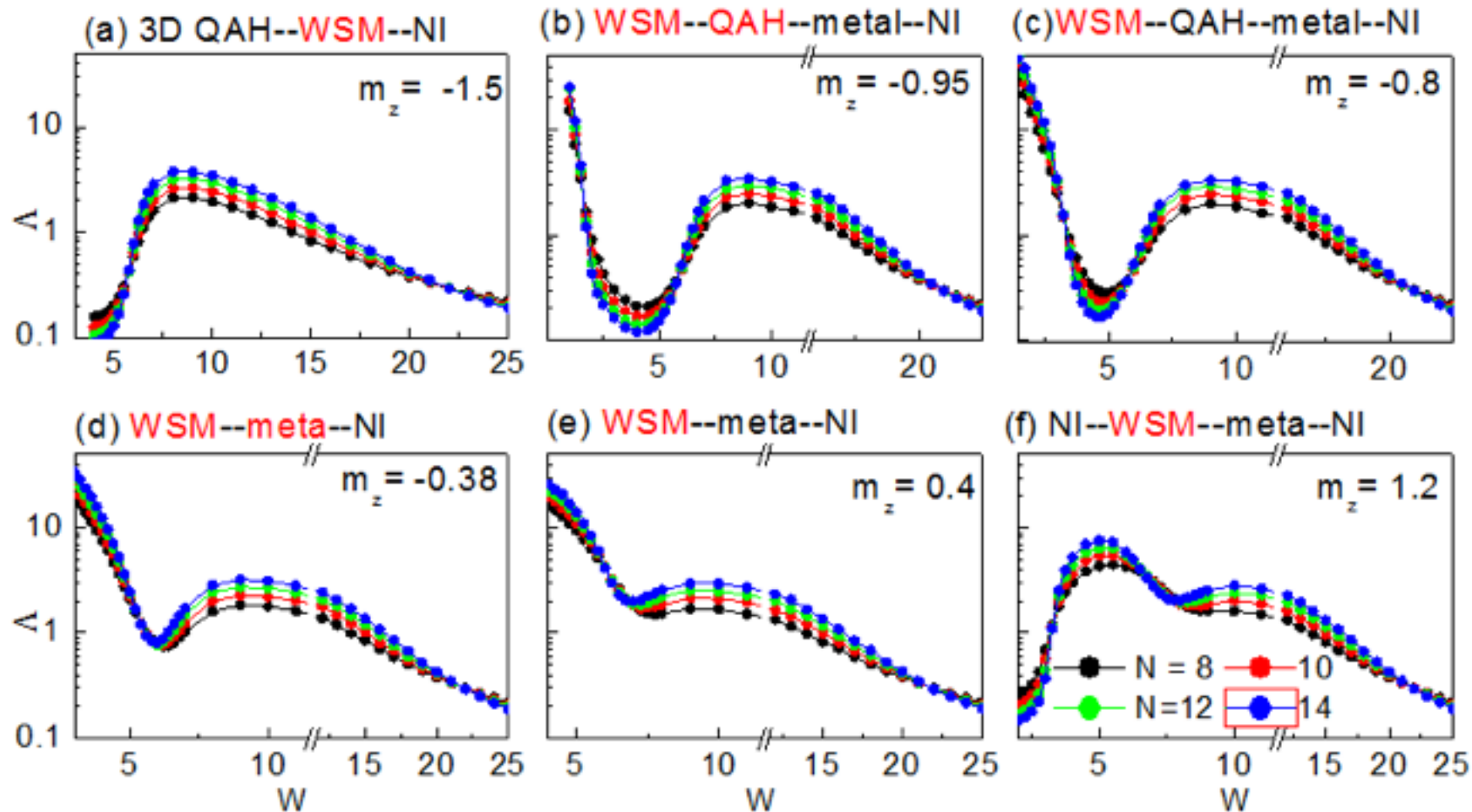
□ Disorder Hamiltonian

$$H = H_0 + \begin{pmatrix} V_1(\mathbf{r}) & 0 \\ 0 & V_2(\mathbf{r}) \end{pmatrix} \quad V_{1,2}(\mathbf{r}) \in [-W/2, W/2]$$

parameters: $t_x = t_y = t_z = 1$,
 $m_0 = 2.1, m_z = -1.5 \sim 1.2$

Multiple Anderson transition

□ Renormalized localization length Λ v.s. disorder strength W



◆ WSM—QAH, NI—WSM : SCBA ◆ WSM—metal: bulk states

Phase diagram and multiple Anderson transition

➤ multiple Anderson transition

□ QAH—metal—NI

□ WSM—QAH—metal—NI

□ WSM—metal—NI

□ NI—WSM—metal—NI

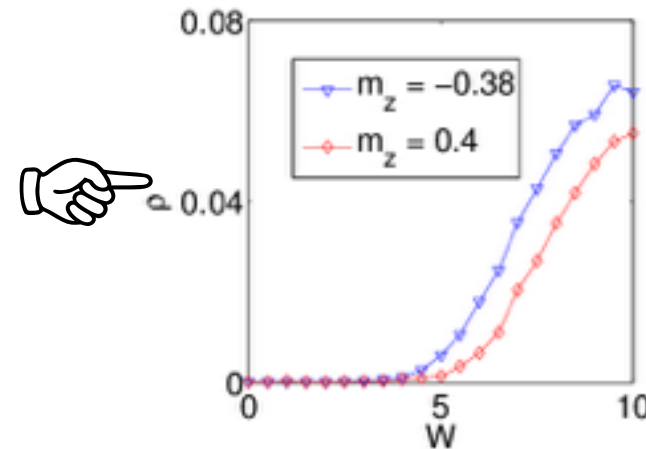
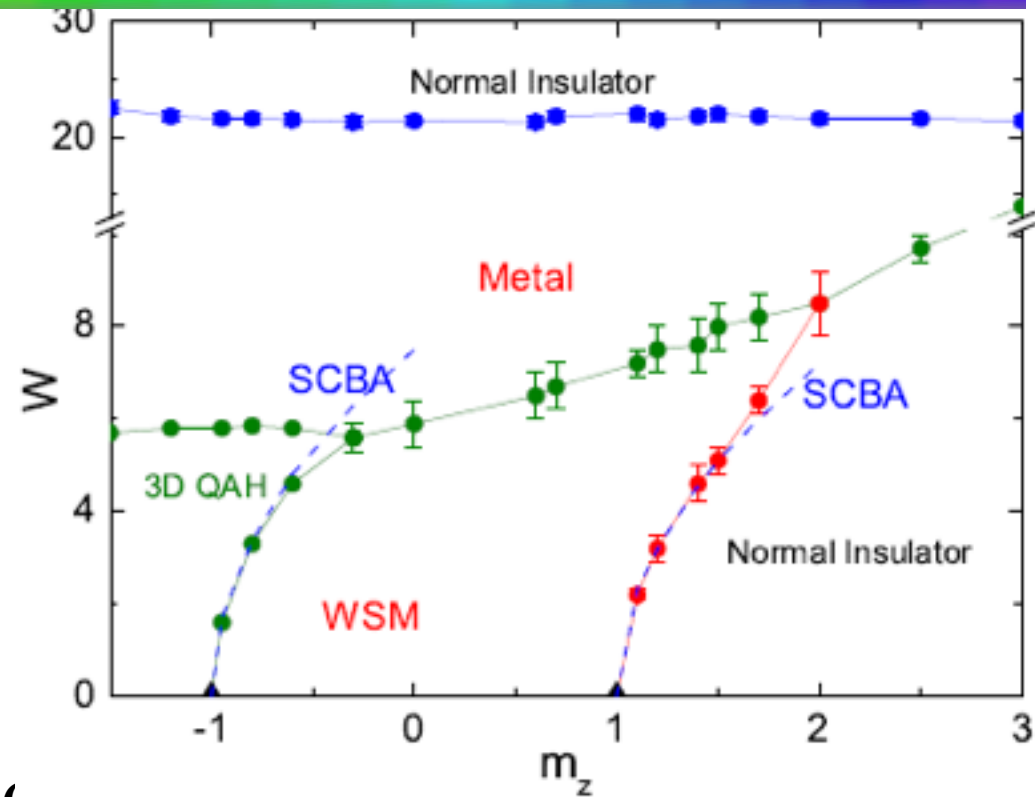
□ NI—meta—NI

➤ Exotic phase transitions

◆ WSM—QAH: nontrivial gap (-----)

◆ WSM—metal: emergent bulk states

◆ NI—WSM : gap closing (SCBA)



Phase diagram and multiple Anderson transition

□ Clean Hamiltonian

$$H_0 = M_k \sigma_z + t_x \sin k_x \sigma_x + t_y \sin k_y \sigma_y$$

where $M_k = m_z - t_z \cos k_z + m_0(2 - \cos k_x - \cos k_y)$

□ Hall conductance of WSMs

$$\sigma_{xy} = \sum_{k_z \in BZ} \sigma_{xy}^{2D} \quad k_z = 0, \pm \frac{2\pi}{N_z}, \pm \frac{2\pi}{N_z} * 2, \pm \frac{2\pi}{N_z} * 3, \dots, \pi$$

$$\sigma_{xy}^{2D}(k_z) = \Theta(k_0 - |k_z|) e^2/h,$$

Weyl nodes $\pm k_0$ with $k_0 = \arccos(m_z/t_z)$

For example $L_z = 8$

$1 < m_z$	NI	$= 0$
$-1 < m_z < 1$	WSM	$= 1, 3, 5, 7$
$-1.5 < m_z < -1$	3D QAH	$= 8$
$1 < m_z$	NI	$= 0$
$-1 < m_z < 1$	WSM	$= 1, 3, 5, 7$
$-1.5 < m_z < -1$	3D QAH	$= 8$
$1 < m_z$	NI	$= 0$
$-1 < m_z < 1$	WSM	$= 1, 3, 5, 7$
$-1.5 < m_z < -1$	3D QAH	$= 8$

NI

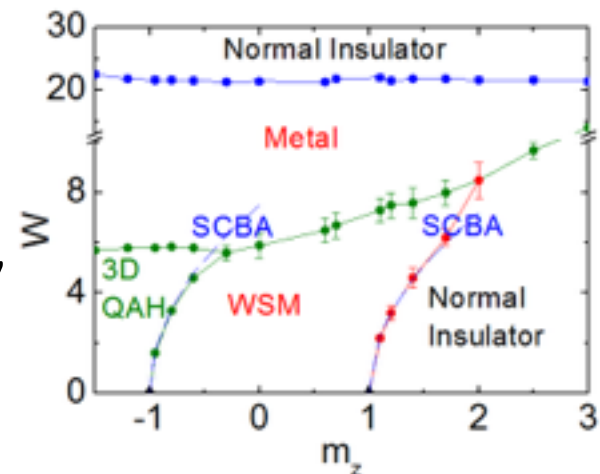
$$\sigma_{xy} = 0$$

WSM

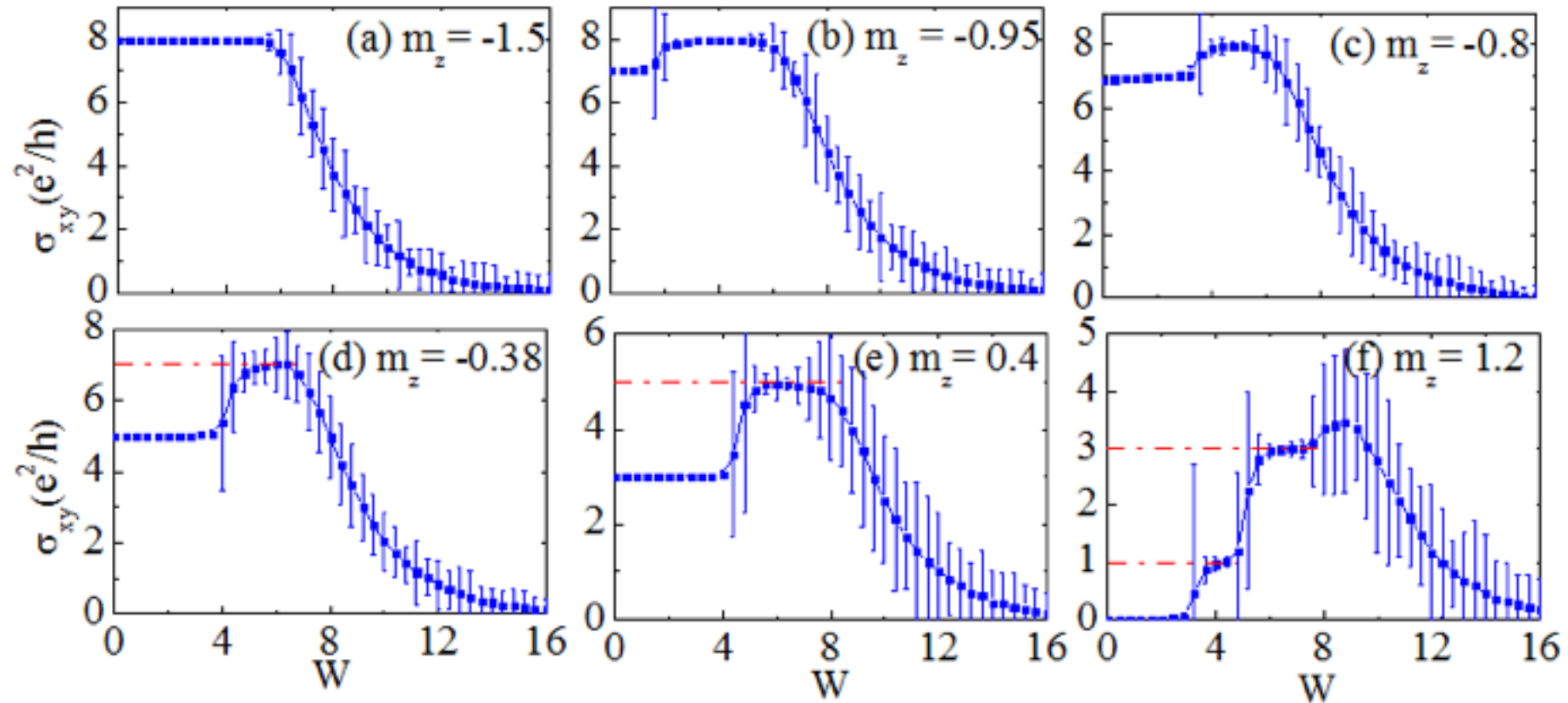
$$\sigma_{xy} = 1, 3, 5, 7$$

3D QAH

$$\sigma_{xy} = 8$$



Surface states and Hall conductance in x-y plane



- WSM--QAH: $\sigma_{xy} = (7 \rightarrow 8) \frac{e^2}{h}$ reach **BZ boundary**
- WSM--metal: **quantized to non-quantized** Hall conductance
- NI--WSM: $\sigma_{xy} = (0 \rightarrow 1) \frac{e^2}{h}$

Conclusion on Anderson transitions in WSMs

➤ multiple Anderson transitions

□ QAH—metal—NI

□ WSM—QAH—metal—NI

□ WSM—metal—NI

□ NI—WSM—metal—NI

□ NI—meta—NI

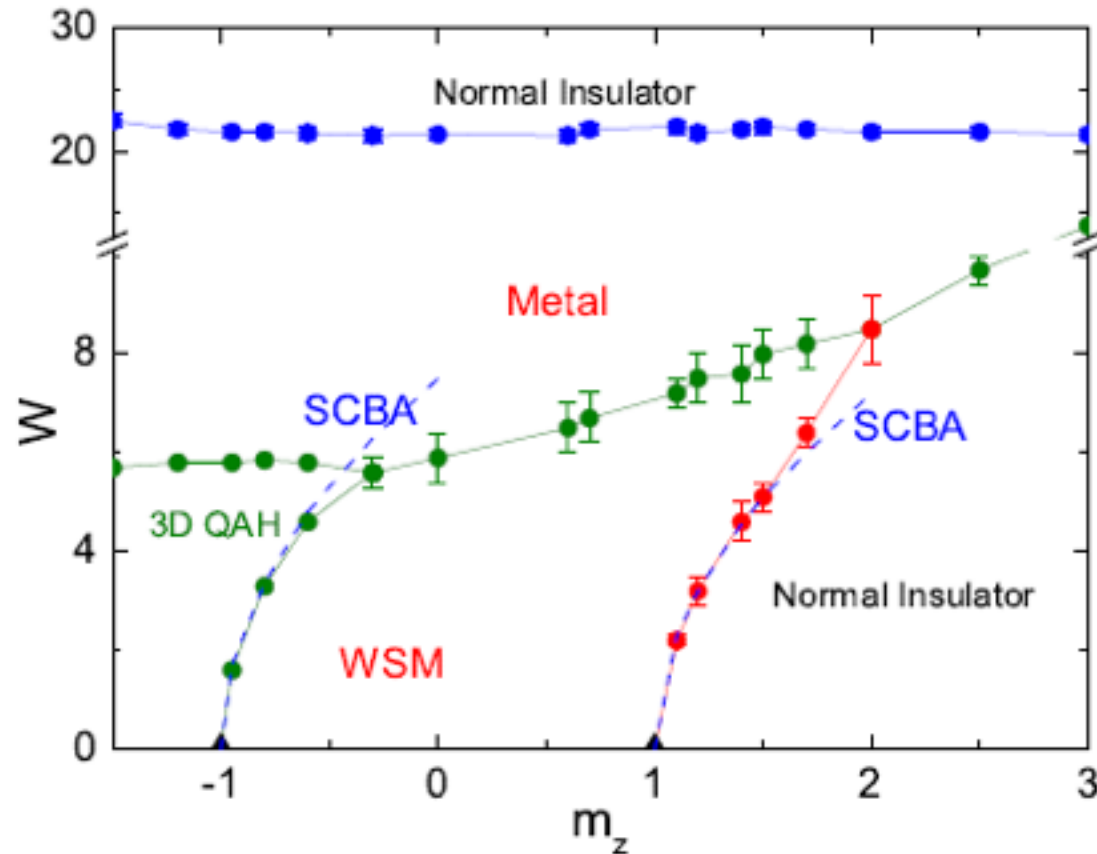
◆ WSM--metal

□ two extended states

□ Hall conductance

◆ WSM--3D QAH

□ SCBA and Hall conductance



Related Publications:



H. Jiang et al., PRL, 103, 036803 (2009);
Q.F. Sun et al., PRL, 104, 066805 (2010) ;
S. L Yu et al., PRL, 107, 010401 (2011);
H. Jiang et al., PRL, 112, 176601 (2014) ;
H. W. Liu et al., PRL, 113, 046805 (2014);
H. Jiang et al., PRB, 80, 165316 (2009);
H. Zhang et al., PRB, 83, 115402 (2011);
L. Wang et al., PRB, 84, 205116 (2011);
X. L. Liu et al., PRB, 83, 125105 (2011);
J. T. Song et al., PRB, 85, 195125 (2012);
D. W. Xu et al., PRB, 85, 195140 (2012);
L. Wang et al., PRB, 85, 235135 (2012);
X. L. Liu et al., PRB, 85, 235459 (2012);